

CONDUCTIVE FILM COMPOSITE**Related Applications**

This application is related to copending applications

- 5 Serial No. 08/488,469 (Attorney's Docket No. 4235)
 Serial No. 08/474,439 (Attorney's Docket No. 4237)
10 Serial No. 08/483,342 (Attorney's Docket No. 4238)

each of which was filed on even date herewith.

Brief Description Of The Invention

- 15 A conductive film composite that comprises an electrically conductive metal foil adhesively bonded directly to a moldable, essentially nonconductive thin thermosetting resin film. The conductive film can be precisionally debossed on the metal foil surface to transmit the debossed pattern to the resin film. If
20 the debossed pattern comprises the grooves and sockets suitable for a printed board, then the conductive film can replicate a printed circuit pattern on curing the thermosetting resin. The stamped conductive cured film can be used to create a printed board or a tool
25 for making printed boards.

Background To The Invention

- The term "printed board" ("PB") is understood to be a general term for completely processed printed circuit or printed wiring configurations. It includes
30 rigid or flexible boards (organic or ceramic) and single, double, and multilayer printed boards. A "printed wiring board ('PWB') is a subset of the PB. It is a board with only printed-on point-to-point connections. A "printed circuit board" is another subset

of PB. It is a board with printed-on components as well as point-to-point connections. In the following description, reference to PB's is intended to encompass PWB's and PCB's.

5 A typical PB is a flat board that holds chips and other electronic components. The board is made of fiberglass reinforced thermosetting resin laminate. It interconnects components via conductive metal pathways. The typical resins used in making PB's are brominated bisphenol A type epoxy resins, bis-maleimide
10 resins and polyimide resins. The resin is typically impregnated into a fiberglass fabric and with compression molding. The impregnated fabric (the "prepreg") is laminated into a multi-ply structure, containing as
15 many as 4 or more plies. Such a structure provides a high fiberglass to resin ratio.

 The conventional printed circuit is an etched circuit. It is made by a photo imaged chemical etch process. A copper foil laminate is covered with a photoresist. U.V. light is shined through a negative image of the circuit paths onto the photoresist, hardening the areas that will remain after etching. The piece is then treated to remove the unhardened areas of the photoresist. When passed through an acid bath
20 (e.g., ferric chloride solution), the exposed copper is etched away. The hardened areas of photoresist are stripped off. An oxide treatment is applied to the copper to achieve proper bonding to the next layer of laminate or for the top layer, a solder mask layer is
25 applied. A similar process creates the microminiaturized circuits on a chip.
30

 In particular, the electrical laminates used in PB's comprise thermosetting resin as described immediately below, impregnated glass continuous filament fi-

ber or fabric systems which are combined with copper foil and pressed in a multi-daylight press into laminates. Laminates have either one or both sides clad with copper. Resin matrix-reinforcing systems range from moderately inexpensive materials such as phenolic/paper laminates or polyester/glass to general purpose epoxy/glass known as FR-4 to high performance (expensive) systems based on bismaleimide-triazine (BT)/glass or polyimide (PI)/glass. Most laminates are pressed/cured in multi-opening presses. At least one company manufactures an epoxy/polyester hybrid copper laminate in a continuous operation.

These different electrical laminates are distinguishable thermally by comparing their respective T_g 's:

	$T_g, ^\circ\text{C}.$
Phenolic/Paper	90
Polyester/Glass	~100
Epoxy/Glass	~125
BT/Glass	225
PI/Glass	260

Hybrids of these above resin matrices are coated onto glass and pressed/cured into laminates with intermediate T_g 's:

	$T_g, ^\circ\text{C}.$
Epoxy/BT-glass	160-200
Epoxy/PI-glass	200-260

The FR-4 varnish which is coated onto glass is a complex mixture of epoxy resins, catalyst, amine accelerator and solvents. Glass reinforced prepreg of brominated epoxy resin catalyzed by dicyandiamide (dicy) with an amine accelerator is "B staged" into dry prepreg sheets with flow varying from 8 to 30%. Flow values aid in selecting the proper press/cure cycle in the manufacture of multiply (FR-4) copper clad laminates. Typically these multiply prepregs are com-

bined with copper foil and pressed in a multi-opening press at as high as 1000 psi, 350°F and requires 30 to 60 minutes for complete cure. A schematic of the overall operation is illustrated in Figure 7.

5 Some excess resin flash that must be trimmed develops on the sides of the laminate and results in laminate variability. Caul plates, used in pressing the laminates, periodically build up epoxy residue causing laminate imperfections and rough surfaces. After many
10 pressings, caul plates must be cleaned by a costly grinding/resurfacing or chemical operation.

 A maximum level of resin cure is essential for ultimate mechanical properties and dimensional ability for stress free laminates. If not properly cured,
15 problems are amplified during the ensuing processing steps leading to a PB. A partially or incompletely cured laminate causes resin smear (flow) during the drilling operation (aligning and assembling laminates into multi-layer boards). Resin flow and deposits on
20 drill bit cause misalignment and possible rejection of the completed PB during final testing.

 Mechanical and electrical properties comparison of phenolic paper and epoxy/glass (FR-4) clearly identify FR-4 as the superior material. On a cost performance
25 basis, the FR-4 board is the predominant material for PB in the U.S. With more pre-assembled devices (surface mount devices) and a significant shift to multi-layer boards, the thermal/mechanical limits of FR-4 are being exceeded by lengthy thermal excursions
30 caused by newer assembly technologies.

 A significant problem associated with double-sided and multi-layer boards (MLB) is plated through hole (PTH). The process of forming the copper plated through hole involves fabricating holes through each

of the laminate layers, preparing the hole for plating, sensitizing the hole with electroless copper and finally electroplating with copper to the desired thickness. Studies have shown that PTH can only survive "few thermal cycles" (Z axis expansion of FR-4) before copper fatigue/failure occurs. One company reports 220 ppm/°C for Z axis FR-4 by TMA mid-point between 50°C and 250°C. The mismatch of coefficient of thermal expansion ("CTE mismatch") between the copper "barrel" PTH and FR-4 results in cracked pads, barrels and/or layer delamination.

This point is described by Harper and Miller, Electronic Packaging, Microelectronics, and Interconnection Dictionary, McGraw-Hill, Inc., New York, NY, 1993, in their definition of "Z Axis":

"(1) The direction through the thickness of a substrate, a feature especially important for printed wiring board laminates, since thermal expansion in the Z axis is much higher than in the X-Y [sic] axis. This is because the resin in the laminate controls the Z axis thermal expansion, whereas the fabric in the laminate controls the X-Y axis thermal expansion. Resins have much high[er] thermal expansions than do fabrics. (2) The direction perpendicular to the fibers in a woven fiber-reinforced laminate — namely, through the thickness of the laminate. Thermal expansion is much higher in the Z axis, since this expansion is more controlled by the resin in the laminate."

There are a number of improvements with respect to PB manufacture that are sought by the industry. One is in the area of cost reduction. Another relates to reduction in the capital investment of a production line to produce PB's. A third improvement involves

the environmental problems that plague the current processes for making PB's. A fourth improvement is a greater circuit density that requires finer lines and spaces.

5 For example, the photo imaging and etch processes involve expensive capital equipment and hazardous chemicals. A photoresist coater is required, followed by a UV exposure machine, followed by a rinse that generates contaminated water waste. This is followed
10 by an etching line that usually consists of 2 to 5 etch tanks and 10 to 15 rinse tanks, all of which generate toxic waste.

 The essence of a PB is to provide the circuit pathways carrying electrical pulses from one point to another.
15 The pulses flow through on/off switches, called transistors, located in chips, which open or close when electrically activated. The current flowing through one switch effects the opening or closing of another and so on. Small clusters of transistors
20 form logic gates, which are the building blocks behind all this magic, and a specific combination of logic gates make up a circuit.

 Today's chip is typically an integrated circuit. Chips are squares or rectangles that measure approximately
25 from 1/16th to 5/8th of an inch on a side. They are about 1/30th of an inch thick, although only the top 1/1000th of an inch holds the actual circuits. Chips contain from a few dozen to several million electronic components (transistors, resistors, etc.).
30 The terms chip, integrated circuit and microelectronic are synonymous. Chips are generally characterized by their function.

 The chip relies on single crystal silicon wafers onto which an electrical circuit is provided. Layers

of these wafers can be used to define the function of the chip. The crystal is then placed in a lead frame, with extending copper and nickel alloy leads. The frame is packaged (encapsulated) with an epoxy molding compound such as an epoxy cresol novolac ("ECN") resin. The encased chip is adhesively bonded to the PB with an epoxy resin adhesive that requires heat to cure. The chip leads are then bonded, e.g., by soldering, to the PB's metal circuitry.

10 The current PB technology is reaching its limits in terms of how fine circuit lines can be made economically while the decreasing sizes of portable electronic equipment will demand even finer lines.

15 It is well recognized that a byproduct of miniaturization of a PB and a chip is speed. The shorter the distance a pulse travels, the faster it gets there. Greater miniaturization allows greater area availability for more circuitry, thus allowing for more functions to be added to the circuit. The smaller the components making up the transistor, the faster the transistor switches. The same effect holds true with respect to a PB. Switch times of transistors are measured in billionths and trillionths of a second. In fact, a Josephson junction transistor has been able to switch in 50 quadrillionths of a second. Thus a tremendous impetus exists to reduce the size of chips and PB's, and in the case of PB's, to reduce the distance between interconnected functions on the PB.

25 George D. Gregoire, Dimensional Circuits Corp., San Diego, CA, 92126 in a paper entitled "Fine-line 'Grooved' Circuitry — A New PB Process for SMT," describes an evaluation of his process in making and employing common PB in surface mount technology (SMT) application, which is in part the technology described

in U.S. Patents Nos. 4,912,844 and 5,334,279. [Surface mounting is a circuit board packaging technique in which the leads (pins) on the chips and components are soldered on top of the board, not through it. As a result, boards can be smaller and built faster] From this analysis, Mr. Gregoire defines what he calls "an improved circuit trace geometry and manufacturing process for PB's containing 'grooved traces' or 'dimensional circuitry.'" The manufacturing process employs a hot stamping approach to form dimensional circuits. According to the author, major parts of the process embrace:

- * molding is effected in a laminating press with ordinary panel-sized laminate materials (e.g., epoxy-glass, polyimide, etc.) in prepreg form;
- * tooling cost, even for low volume, is nominal;
- * chemicals and steps used for copper metallization is traditional, yet high, benchmark-level FR4, adhesion is achieved, as high as for pre-clad PB's;
- * the following traditional PB production steps are omitted:
 - production phototooling (film)
 - dryfilm plating resist
 - film-to-PB registration (features are molded in)
 - imaging
 - developing, and
 - possibly, solder resist in its entirety.

A small amount of common etch resist is used in a "self-locating" way, bladed on, with no registration steps required. The resist is stated to be retained, and protected in the grooves, below the surface, during etching.

In defining the significance of this technology to users, Gregoire states that it dramatically improves soldering yields during fine-pitch surface mounting. He states that groove circuits provide yield improvements in the self-locating feature during assembly because the grooves or channels allow SMT IC leads to automatically self-locate. The self-locating feature provides yield and quality (e.g., much higher lead pull strength) improvements. The wide, funnel-shaped and deep channels completely wick and fill with solder, making automatic allowance for the skew and out-of-planarity problems that come with high lead count, fine-pitch ICs.

A significant deficiency of the molding step of this process is its use of thermosetting resins in prepreg form, which means that the prepreg sheet contains a glass fiber fabric to reinforce the epoxy resin. The specific ones mentioned are epoxy-glass, and polyimide, without specifying the fiber. In the latter case, it is assumed that the fiber is glass fiber. That requires the hot stamping into an unyielding fiber mass that restricts resin flow and resists well-defined debossment. Moreover, a resin-glass fiber prepreg creates an anisotropic substrate creating CTE mismatches for any copper layer deposited thereon, due to the surface irregularity of that material. As pointed out above, this results in "cracked pads, barrels and/or layer delamination," clearly indicating why such a substrate is not favored by Gregoire.

Parker, U.S. 4,912,844, describes punching an optionally planar surface with a punch that may be heated to impart grooves and cavities in the surface. The punch may have foil disposed on it so that it is transferred to the substrate and in the grooves and

cavities in the substrate. The portions of the foil on the surface of the substrate may be removed by printed circuit techniques or machining or laser techniques so that only the portions of the foil in the grooves and the cavities remain. Figures 5-8 of the patent list alternative steps in producing a printed circuit. They are listed in the following table:

Figure 5	Figure 6	Figure 7	Figure 8
Dispose a mark on a flat surface of a punch.	Machine or laser cut the punch to create raised portions.	Start with a flat surface of a punch	Press metal foil around punch to make foil conform to raised portions of the punch.
Photo expose an image of desired grooves and holes on the mask of the punch.	Heat the punch to an elevated temperature.	Coat the flat surface with a photo-resist material in a pattern corresponding to the desired pattern of grooves and holes in the substrate.	Heat punch and foil to an elevated temperature.
Etch the photo exposed image of the grooves and holes on the mask.	As an alternative or as an additional step, heat the substrate.	Remove the portions of the punch without the photo-resist material.	As an alternative or as an additional step, heat the substrate.
Plate the etched portion of the mask to fill the holes and grooves in the mask.	Apply the punch to a surface of the substrate to form the grooves and holes in the substrate.	Harden the photo-resist material on the substrate.	Press foil on and into surface of substrate to produce grooves and holes in the substrate.
Remove mask from punch.	Remove the punch from the substrate.	Heat the punch to an elevated temperature.	Remove foil from surface of substrate while retaining foil in grooves and hole in substrate.
Heat the punch to an elevated temperature.	Dispose electrical components in the holes in the substrate.	As an alternative or as an additional step heat the substrate.	Dispose electrical components in the holes in the substrate.
As an alternative or as an additional step, heat the substrate.	Apply an electrically conductive material such as solder to the grooves in the substrate to establish electrical continuity with the electrical components.	Apply the punch to a surface of the substrate to form the grooves and holes in the substrate.	Apply an electrically conductive material such as solder to the grooves in the substrate to establish electrical continuity with the electrical components.
Apply the punch to a surface of the substrate to form the grooves and holes in the substrate.		Remove the punch from the substrate.	
Remove the punch from the substrate.		Dispose electrical components in the holes in the substrate.	
Dispose electrical components in the		Apply an electrically conductive material	

holes in the substrate.		such as solder to the grooves in the substrate to establish electrical continuity with the electrical components.	
Apply an electrically conductive material such as solder to the grooves in the substrate to establish electrical continuity with the electrical components.			

An advantage of the PB procedure of U.S. 4,912,844, is the exploitation of grooves and cavities in the board to provide the printed circuit. This allows one to create the surface area needed for obtaining low electrical resistance in the wiring placed in the grooves and associated with the cavities. Note that the depth of the grooves are preferably at least as great as the widths of the grooves and since the solder can fill the grooves, the widths of the grooves can be made quite small while still retaining relatively low electrical resistance. In a number of instances, such as at column 4, lines 9-19, column 5, lines 4-8, lines 9-16, lines 18-19, the patent utilizes heating of the substrate to deform it, using temperatures up to the melting temperature of the substrate. This demonstrates that the substrate must be heated above a glass transition temperature in order to achieve flow. On the other hand, the patent also states that the PB's can be made of a ceramic or an epoxy-glass material. In addition, the patent states that the substrate may also be made of high temperature thermoplastic or thermosetting materials without specifying what they may be or their properties. The patent is devoid of details on how the metal foil is bonded to the thermosetting or thermoplastic substrate, and how one avoids a CTE mismatch, as characterized above. For example, a metal foil will not

tightly bond to a thermoplastic substrate even if the substrate is melted in contact with the foil; an adhesive is required to effect reasonable bonding of the foil to the thermoplastic substrate. This appears to
5 be recognized in the Gregoire's recently issued U.S. 5,390,412 that specifies the use of an "adhesion promote coating" that involves forming a "dendritic oxide coating" by bathing in a "water base bath" in order to bond an electroplated copper layer to a dielectric
10 substrate.

Gregoire, U.S. 5,334,279, relates to a PB tool for producing three-dimensional PB's having grooves with strongly bonded or laminated metallic pads therein. The circuit board tool comprises a metallized male
15 mold substrate having a plurality of groove forming projections. The metalized mold substrate is made from a female parent or predecessor master tool. The patent articulates a three-dimensional PB that employs a high heat deflective plastic, without defining the
20 plastic, and a plurality of recesses or grooves molded into the substrate surface for receiving the fine pitch, closely spaced-apart leads, of an integrated circuit.

Gregoire, U.S. 5,351,393, is another patent in this
25 area.

The Gregoire and Parker patents, all assigned to Dimensional Circuits Corp., directed to technology for simplifying PB manufacture, demonstrate the complexity of making tools and making PB's from the tools. One
30 of the reasons for such complexity is that the materials of construction that are used for tool making and for printed wire boards are undefined or improperly designed for a simple and effective PB construction that avoid CTE mismatches and for making tools that

can be used in shaping plastics and resins into printed wire board substrates, whether containing or not containing grooves and cavities.

5 The art of making PB's is restricted by the processes and material from which they are made. Labor intensive techniques such as stenciling, silk screening, masking, etching, and the like, drive up the cost of PB's. There is a need for a simple and cost effective method for making PB's that has the capacity of
10 minimizing the required use of labor intensive techniques.

The Invention

This invention relates to the materials and their combination to produce a thin foil-laminated adhesive
15 dielectric thermosetting resin film that is amenable to being subjected to a mechanical debossing procedure that imparts a debossed and/or embossed printed circuit pattern directly thereon. Also, the invention relates to the method of making this laminate and the
20 debossed and/or embossed laminate. The components of this invention can be used in forming a PB or any other fine line circuitry elements that avoid CTE mismatches. The invention also relates to the formation of a PB from these components.

25 There are descriptions in the art referring to press stamping of foil and thermosetting resins and thermoplastic polymers. Those descriptions merely characterize the forming of debossed surfaces, such as grooves, channels and cavities, in a composite of foil
30 and resin/thermoplastic without defining with reasonable precision the materials from which the composite is formed. To the extent that materials are defined, they are generically and very generally described. For example, as noted above, an epoxy-glass prepreg

was described in U.S. 4,912,844, without any characterization of the epoxy resin or the glass filament reinforcement. The same is true with respect to selection of thermoplastic polymer. In addition, there
5 is no definition of the dimensions of the resin/thermoplastic polymer component in the composite.

Thin metal foils are very easy to deboss. A stamp press can be used to impart grooves, channels and
10 sockets in a metal foil. The depth of such debossment can be quite large or nearly "infinitesimally" small. However, such foil is flimsy, and lacks strength and rigidity. Conventional thermosetting resin formulations are difficult to shape into thin films, in particular, to thin films that can be debossed so as to
15 retain a debossed and/or embossed circuitry image in the film. Such films, on standing and when heated to effect cure without edge restraint, lose definition of any or substantially all of the impressed debossed pattern even when affixed to the mold. In addition, a
20 conventional thermosetting resin may not have the adhesive properties to adequately bond to a metal foil during a lamination procedure though the art possesses substantial knowledge about thermosetting adhesives that bond to metal foils such as copper foil. As noted
25 above, U.S. 5,390,412 requires the creation of an oxide layer interface between the metal foil and the dielectric substrate in order to achieve bonding. More importantly, in such laminate construction, a conventional thermosetting resin may not properly flow in a
30 debossing process so as to form a desirable bond between the foil and resin films coupled with a satisfactory debossed/embossed pattern in the composite. This is especially the case with compositing a metal

foil and a thermoplastic film. High performance thermoplastic polymers, commonly characterized as performance polymers and engineering polymers, do not possess good adhesive properties. A metal foil film stamp
5 pressed into such a polymer film will possess weak adhesion rendering the composite unsuitable for most applications, and assuredly so with respect to PB's.

It has been found that thin uncured dielectric thermosetting resin films, properly formulated, can be
10 sufficiently directly bonded to a heat and electrically conductive metal foil to form a composite that can be debossed through the foil surface to retain the debossed/embossed pattern in the metal foil and the attached resin film of the composite. The composite
15 can be subjected to conditions that effect cure of the thermosetting resin, and the thermoset resin provides a dielectric substrate. For example, that debossed/embossed laminate can then be subjected to an elevated temperature while the composite is affixed to
20 or free of the debossing mold surface (the mold surface is an embossed surface, the male representation of the female debossed surface), to gel, near-gel or cure the adhesive resin formulation. Such gelling or near-gelling, and cure fixes the debossed/embossed
25 pattern in the metal foil layer and the resin layer of the composite sufficient for curing and/or post curing the composite, as the case may be. This can be effected with minimal loss of debossment/embossment precision for eventually generating a PB or for forming a
30 tool useful in effecting the debossment procedure. The debossed/embossed pattern can replicate an electrical circuit typical of the most complicated PB's industrially available. The foil and the resin film can be extremely thin and the composite can have a

thickness thinner than most of the commercially available PB's, and typically as thin as the most advanced state of the art PB's. Of particular desirability is that the mechanical debossment process allows for the generation of exceedingly fine line debossed and/or embossed electrical circuitry in the device.

The composite of the invention can include a thin layer of thermoplastic polymer, such as a performance or engineering plastic. The thin layer of thermoplastic polymer contacts the uncured thermosetting resin adhesive film which in turn contacts the metal foil. Thus, the three-layer laminate precursor comprises a metal foil layer that in combination with the thermoplastic polymer film layer, sandwich the thermosetting resin adhesive film layer. The laminate can be debossed/embossed at a cure, near-gel or gel temperature of the thermosetting resin through the metal foil surface, so that debossment is transmitted through the thermosetting resin layer and into the thermoplastic polymer layer.

The thin foil-laminated dielectric thermosetting resin film has the capacity of being precision stamp molded through the thin foil surface with a patterned tool. The pattern comprises embossed fine lines characteristic of the electrical circuit of a PB. The stamping causes debossment/embossment of the laminate to form a debossed and/or embossed electrical circuit pattern comprising grooves, cavities, channels, ridges, sockets and/or plateaus (raised segments), and the like. This can be effected at a relatively low temperature, such as temperatures as low as room temperature (~23.5°C.), with superior duplication of the pattern that can be retained in the eventually cured resin laminate. Because the electrical circuitry is

formed by debossment into the thermosetting resin, the space that the circuitry occupies on the surface of the board is much smaller than the space of circuitry in a comparable conventional flat board PB's. The amount of deposited metal in each circuit line debossed into the thermosetting resin provides the desired level of conductance while the surface area of the board occupied by the circuit line is much less, Because of the finer circuit lines that can be provided, a PB according to the invention may be made smaller and thinner than conventional PB's.

The electrically conductive metal foil desirably has an uniform thickness, as characterized below. The surface conductive film can be precisionally debossed on the conductive metal foil surface to transmit the debossed and/or embossed pattern into the dielectric resin film. If the pattern comprises grooves, ridges and sockets suitable for making a PB, then that pattern is permanently fixed within the composite by curing the dielectric thermosetting resin film. The grooves, ridges and/or sockets can replicate a printed circuit pattern. In order to achieve such results, the dielectric resin film component of the composition should have an unimpeded thickness that is at least equal to that of the foil film bonded to it. Preferably, the dielectric resin film has an unimpeded thickness that is at least the thickness of the foil and as thick as 250 times the thickness of the foil. Preferably, the film has an unimpeded thickness that is at least about 1.2 times thicker to 25 times thicker than the thickness of the foil. Most preferably, the film has an unimpeded thickness that is at least about 2 to about 10 times thicker than the thickness of the foil. Typically, the thickness of the thin laminated compos-

ite comprising the foil and the unimpeded resin film is from about one (1) mil (0.00254 cm) to about two hundred fifty (250) mils (0.635 cm).

5 In the typical case, the unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film. An unimpeded resin film is an uncured mass that contains no restrictions to the impressed metal foil. Such restrictions comprise continuous filament fiber as is found
10 in a typical prepreg, fabric as is found in typical resin impregnated fabric, paper as is found in a typical impregnated paper, and the like.

The cured stamped conductive film composite can be used to create a PB or a tool for making PB. As such,
15 it is appropriate to term the composite as a precursor to making a PB. In addition, the cured stamped conductive film can be treated to remove metal foil from surface portions of the film that are not to be part of the electrical circuit of the PB. Consequently,
20 the laminated foil precursor can be used to form a major part or all of the circuitry of the PB. One advantage of this invention is that PB's made this way can be made to be stackable and used in forming three dimensional PB's where the electrical connections between the stacked molded laminates may be through
25 holes (PTH) extending through one or more layers of the stack and/or by connecting plastic tape circuits between the layers of the stack. This can be effected without some of the deficiencies noted above in respect to PTH problems in the prior art boards. In-
30 deed, the molded pattern may include sockets (or cavities) or plateaus for chip components and trenches, furrows, grooves, channels or ridges between the sockets that are allocated for circuitry. In this form,

the stacked PB's will exhibit the maximum compactness and hence allow for optimum miniaturization.

5 The conductive laminated cured film of the invention is useful as a female or male tool for making a PB by stamping another film (with or without metal foil) having the same or similar composition.

10 The invention also contemplates a foil-laminated thin film of a thermosetting resin that contains *in situ*-expandable thermoplastic particles that contains an essentially uniform density and thickness across the breadth of the film. In this embodiment, pressure built up in the interior of the film during curing causes the film to expand. The invention contemplates placing such a foil-laminated film in contact with an debossing stamp containing a replicative printed circuit pattern in male embossed or female debossed relief form and heating the film at a temperature that causes the *in situ*-expandable thermoplastic particles to expand forcing the foil into the debossing stamp's embossed surface to generate a debossed/embossed pattern in the foil-laminated expanded film.

15 The invention also contemplates laminating the aforescribed metal foil-thermosetting resin laminate to a supporting layer comprising a thermoplastic polymer film, a fabric and/or a composite of a fabric and a thermoset or thermoplastic polymer impregnated fabric. The supporting layer is preferably bonded to the thermosetting resin layer of the laminate. Bonding is effected by relying on the adhesive qualities of the thermosetting resin layer. In making such laminates, 25 the metal foil is debossed into the thermosetting resin layer of the laminate or through the thermosetting resin layer into the supporting layer, in which case the metal foil is bonded to the supporting layer, 30

typically by virtue of the adhesive qualities of the thermosetting resin layer of the laminate.

5 The invention of debossing thin metal foil-thermosetting resin laminate can be carried out in a batch, semi-continuous or continuous process. In a batch process, the various films are superimposed on a platen of a platen press and subjected to debossment in the press, and the resulting composite is removed. One or both of the platens can contain the tool with
10 the desired surface mold containing the required grooves, ridges and chip and other device sockets and/or plateaus necessary for a PB. Typically, the tool will be located on the metal foil side of the composite so that an impression is effected by the
15 tool into that surface. One or both platens may be heated to effect gelation or near gelation ("near-gel" state) of the resin film, thereby fixing the metal foil in the resin film. Neither platen need be heated so that debossment takes place under ambient condi-
20 tions. In both cases, the debossed composite can be removed from the platen press and put in an oven to cure or post cure the resin and fix the debossed metal foil in the cured resin.

25 The semi-continuous process involves the prelamination of the metal foil film and the resin film in a continuous mode to form scrolled rolls of the uncured composite. The uncured composite can be unscrolled, or the continuous formation mode can be accommodated with take up rolls, then cut into pieces designed for
30 debossment in a press, such as a platen press, containing a tool as described above, that can debossed through the foil surface. The pieces are placed into the press and with compression of the platens, the grooves, ridges and/or sockets, i.e., the printed cir-

cuit pattern, are formed through the metal foil surface, into the resin film, and any other associated layer. Gelation, near gelation or curing through heated platens, as described above, takes place next.

5 If desired, the debossed composite is removed from the press and subjected, as required, to oven treatment to cure or post cure the resin.

The continuous process involves the same prelamination step of the semi-continuous process. However,
10 rather than batch cut and deboss the laminate, the laminate is fed continuously as a continuous film of the composite to nip rollers or the combination of an endless belt and rollers, or two endless belts, in which the roller or belt that contacts the foil side
15 of the composite contains the tool with the printed circuit pattern on its curved surface. The debossment of the composite takes place continuously by moving the nip roller or belt combinations at the same speed as the composite being fed to the rollers. The rollers
20 can be heated at a sufficiently high enough temperature to cause the composite's thermosetting resin to near gel, gel or cure, thereby fixing the debossment in the composite. The heated composite film can be fed directly to a continuous oven where the resin
25 is cured or post cured, and then the film can be cut to isolate each debossed section that defines a printed board.

In respect to any of these procedures, there may be included a pre-debossment step in which the surface of
30 the metal foil that is to contact the thermosetting resin film, or the thermosetting resin film, has printed on it a release agent coating that replicates the printed circuit pattern which is to be debossed into the foil-resin composite. The printing avoids

coating those sections of the pattern that will constitute debossed/embossed portions of the pattern. The remainder of the pattern contains the coated release agent. The printing may be effected by a release agent deposition step effected by transferring
5 release agent from

1. transfer sheets, typically thermoplastic film or release paper, to the metal foil film, or
2. through screens such as by silk screens, to the
10 metal foil film, or
3. rotogravure rolls, to the metal foil film.

The transfer sheets can be formed by rotogravuring the release agent to the transfer sheet. The silk screening process can be effected using flat or rotary
15 screens, as desired. Coating of the resin film surface with a release agent coating is used when the metal deposition on the film is by electroless or electrolytic plating.

The thermosetting resin film used in forming the
20 laminate of the invention has the following qualities:

- a) it will shape by processes such as stamping and compression molding, and the like;
- b) the resin is nonconductive, which means that the resin can be used as a dielectric substrate;
- 25 c) it is a thin film that is sufficiently uniform in thickness in order to provide consistent heat shaping capability across the breadth of the film, and the thickness should be sufficient to accept the shape imposed by the shaping process;
- 30 d) the resin can be molded by compression or stamp molding without the need for constraining flow at the edges of the resin film;
- e) the film possesses low flow over a broad temperature range so that it does not flow uncontrollably while

undergoing cure conditions, and when placed under pressure, only the portions that are superimposed over a groove or cavity in the case of a female mold, or over a protuberance in the case of a male mold, will be caused to flow because of pressure imposed on the film; and

5 f) the film gels or achieves properties similar to a state of gelation ("near-gel" state), over conditions leading to cure, that satisfy commercial conditions.

10 The resin formulation may contain a number of additives that aid in the performance of the resin in forming a dielectric substrate onto which metal foil is deposited. One such additive is a low profile additive.

15 Low profile additives are thermoplastic polymers that have the capacity to cause the cured thermoset resin to avoid shrinkage at the foil resin interface. In fact, low profile additives can serve to slightly expand the surface of the resin so that at

20 the time the foil-resin laminate is undergoing advancement toward resin cure, the low profile additive causes the resin film to slightly expand up to about 2-3%, preferably up to about 1-2%, and this assures that the debossed portions of the printed board pattern are smooth, uniform and devoid, or essentially

25 devoid, of shrinkage. This is particularly advantageous if the metal foil is formed by a deposition process such as electroless and/or electrolytic plating.

30 The foil that is laminated to the thin resin film is a relatively thin sheet of essentially uniform thickness as characterized by ANSI/IPC-MF-150F, § 3.4.3, adopted on October 4, 1991, entitled: "Metal Foil for Printed Wiring Applications," published by

the Institute for Interconnecting and Packaging Electronic Circuits, 7380 N. Lincoln Avenue, Lincolnwood, IL 60646. The foil may have a thickness between about 0.1 mil (2.54×10^{-4} cm) to about 20 mils (5.08×10^{-2} cm);
5 varying ± 10 percent for deposited foils and ± 5 percent for wrought foils. Suitable forms of the foil are of the electrodeposited or wrought forms. The foil sheet may be made of a variety of conductive metals and metal alloys, such as aluminum, copper, chromium,
10 gold, silver, magnesium, nickel, brass, zinc, and the like. Preferred foil metals are aluminum, copper and nickel. Copper grade foils are characterized by ANSI/IPC-MF-150F, at § 1.2.4.1 and such are included in the practice of the invention. The foil sheet may
15 be a separately formed sheet that is adhesively bonded to the thin resin film or the foil may be formed as a sheet bonded to the thin resin film by a metal deposition technique. The metal deposition can be effected by electroless and electrolytic metal plating, by
20 metal sputtering, vacuum deposition, and the like.

The thin, essentially-nonconductive, thermosetting resin film that is adhered to the foil is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,
25

(i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.

30 The resin film has

a) an uniform areal thickness ranging from about 1 to about 250 mils (about 0.00254 cm to about 0.635 cm) as calculated from the weight of resin film for a given area;

- b) with minimum and maximum thicknesses not exceeding the deviation factor set forth in Table A.

Table A

Range in mils	Deviation Factor
1 to 5	± 1 mil (± 0.00254 cm)
5 to 10	± 2 mils (± 0.00508 cm)
10 to 250	$\pm 20\%$

- 5 c) low flow at a broad temperature range;
d) the ability to cure, gel, or near-gel, at temperatures from about 20°C. to about 250°C., in less than about 7 days and more than 1 second;
e) a low dielectric constant in the thermoset state.
- 10 The laminated composite of the foil sheet and the thermosetting resin film have essentially the same surface area.

In a further embodiment of the invention, the moldable, essentially nonconductive thermosetting resin film employs as the flow control agent a diverse group of materials, such as:

- 15 i) one or more electronic grade fillers;
ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;
20 iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin matrix;
iv) a thixotrope; and
v) a mixture of two or more of i), ii), iii) and
25 iv).

Brief Description Of The Drawings

Figure 1a schematically illustrates a side view, in a partially depicted exploded relationship, of a batch process for press stamping the composites of the invention.

Figure 1b shows the side view of a PB precursor containing a metal foil-thermosetting resin laminate.

Figure 1c shows the side view of a PB precursor containing a metal foil-thermosetting resin laminate bonded to a supporting layer.

5 Figure 1d shows the side view of a PB precursor containing a metal foil-thermosetting resin laminate bonded through the thermosetting resin into the supporting layer.

10 Figure 2a shows a schematic side view illustrating a semi-continuous process for press stamping the composites of the invention.

Figure 2b shows the view of Figure 2a incorporating, in addition, a supporting layer.

15 Figure 3a is a schematic side view of a production line for the continuous production of the laminates of the invention.

Figure 3b shows the view of Figure 3a plus the addition of a supporting layer.

Figure 4 is a plan view of a composite of the invention in a printed board format.

20 Figure 4a, taken along line 4a-4a, is a cross sectional side view of the composite of Figure 4.

Figure 4b, taken along line 4b-4b, is a cross sectional side view of the composite of Figure 4.

25 Figure 4c, taken along line 4c-4c, is a cross sectional side view of the composite of Figure 4.

Figure 4d, taken along line 4d-4d, is a cross sectional side view of the composite of Figure 4 containing an additional layer, also shown in cross section.

30 Figure 5a shows abrading of PB according to the invention to isolate the metal foil into grooves and sockets.

Figure 5b shows a side view of a PB according to the invention.

Figure 6 is a top view of a PB made in accordance with the invention.

Figure 6a is a cut away side view of the PB of Figure 6 taken along lines 6a-6a.

5 Figure 6b is a cut away side view of the PB of Figure 6 taken along lines 6b-6b.

Figure 6c is a cut away side view of the PB of Figure 6 taken along lines 6c-6c.

10 Figure 6a is a cut away side view of the PB of Figure 6 taken along lines 6d-6d.

Figure 7 is a schematic view of a prior art system for making PB's.

Detailed Description Of The Invention

This invention includes —

- 15 • thin film printed board precursors that contain a thermosetting resin layer and metal foil layer in direct contact with a side of the resin layer, optionally containing a supporting layer comprising fiber, fabric and/or thermoplastic polymer, in contact with the other side of the resin layer, and
- 20 methods for making such precursors; and
- thin film printed board precursors that contain thermoset resin layer and metal film adhesively bonded directly to a side of the thermoset resin layer, optionally containing a supporting layer comprising fiber, fabric and/or thermoplastic polymer, in contact with the other side of the resin layer, the resulting printed boards and methods for making the precursors and the printed boards.
- 25

30 The process of the invention creates the electrical circuit in the PB by a mechanical pressing action that either debosses or embosses the circuit path on the board. A master tool has the circuit pattern on it as raised lines (embossed) or depressed groves

(debossed). The master tool is made by a conventional photo imaged chemical etch process. A metal tool plate is covered with a photoresist. U.V. light is shined through a negative image of the embossed circuit paths, onto the photoresist, hardening the areas that will remain after etching. The piece is then treated to remove the unhardened areas of the photoresist. When passed through an acid bath (e.g., ferric chloride solution), the exposed metal of the tool plate is etched away. The hardened areas of the photoresist are stripped off leaving a relief image of the embossed pattern to be stamped into the foil.

This pattern is transferred to the PB lamination by a simple pressing operation. Because mechanical replication transfers the pattern to the laminate, a much finer line spacing can be achieved than by photo etching. This can be turned into a metal circuit by a variety of methods. For example:

1. The raised line (embossed) tool is pressed into copper (or other metal) foil that has been placed over the adhesive. This can be pressed in seconds and cured in a later operation, either with the tool in place or removed.
2. That method may be modified by masking the circuit line pattern on a silk screen or by stenciling, and coating the underside of the copper foil, i.e., the side of the foil that contacts the adhesive, with a release agent. After the foil is pressed into the adhesive, and the adhesive is cured, then the foil over the release agent can be abraded to easily separate those sections of the foil from the laminate.

The concept of molding a non-conducting thermosetting resin in order to form a PB is best achieved us-

ing a thermosetting resin having the properties set forth herein. Very few thermosetting resin formulations have the capacity to form a thin film possessing the following collective properties:

- 5 a) the formulation shapes by processes such as stamping and compression molding, and the like;
- b) the resin formulation is nonconductive, which means that the formulation can be used as a dielectric substrate;
- 10 c) the formulation forms a thin film that is sufficiently uniform in thickness in order to provide consistent heat shaping capability across the breadth of the film, and the thickness should be sufficient to accept the shape imposed by the shaping process;
- 15 d) the formulation can be molded by compression or stamp molding without the need for constraining flow at the edges of the resin film;
- e) the resulting film possesses low flow over a broad temperature range so that it does not flow uncontrollably while undergoing cure conditions, and when placed under pressure, only the portions that are superimposed over a groove or cavity in the case of a female (debossed) mold, or over a protuberance in the case of a male (embossed) mold, will be caused to flow because of pressure imposed on the film; and
- 20 f) the resulting film gels or achieves properties similar to a state of gelation, over conditions leading to cure, that satisfy commercial conditions.
- 25
- 30 The average thickness is preferably from about 1 to about 250 mils (about 0.00254 cm to about 0.635 cm).

The invention relates also to the use of a thin isotropic thermosetting resin film with the metal foil layer that is amenable to being subjected to the de-

bossing procedure that imparts a printed circuit pattern thereon. These thin isotropic thermosetting resin films avoid the aforementioned CTE deficiencies of an anisotropic fabric prepreg. This can be effected with minimal loss of debossment precision for eventually generating a printed circuit board that is devoid of CTE mismatch, or for forming a tool useful in effecting the debossment procedure. The thin isotropic thermosetting resin film/foil laminate has the capacity of being precision molded with a tool at a relatively low temperature, such as temperatures as low as room temperature ($\sim 23.5^{\circ}\text{C.}$), with superior duplication of the pattern.

The invention also contemplates associating with the foil layer, a thin isotropic film of a thermosetting resin that contains *in situ*-expandable thermoplastic particles that contains an essentially uniform density and thickness across the breadth of the film. In this embodiment, pressure built up in the interior of the film during curing causes the film to expand. The invention contemplates placing such a film in contact with a debossing stamp containing a replicative printed circuit pattern and heating the film at a temperature that causes the *in situ*-expandable thermoplastic particles to expand into the debossing stamp surface to generate a debossed pattern in the expanded film.

The term "isotropic" means, in the context of this invention, a material possessing essentially the same electrical and physical properties in all directions (e.g., x, y and z) through it. This is to be contrasted with fabric reinforced prepregs. Such prepregs are anisotropic. They exhibit several times differences in properties between the x, y and z di-

rections. In the case of this invention, the films do not exhibit differences in electrical and physical properties by more than 20% in any direction.

5 There are many commercial thermosetting resin systems that can be used to produce a thin pliable adhesive thermosetting resin film. For example, certain of such films are employed in Synspand® and Syncore®, expanded or expandable films that are sold by The Dexter Corporation. However, another of a special subset
10 of such a resin system is a thin isotropic thermosetting resin film that is amenable to being subjected to a debossing procedure that imprints a printed circuit pattern thereon without creating mismatches of coefficient of thermal expansion ("CTE") between the copper
15 deposited thereon that could result in cracks in grooves, sockets, pads, etc. Such a resin film should be capable of effecting debossment precision sufficient to eventually generate a PB or for forming a tool useful in effecting the debossment procedure
20 leading to the PB. The thin thermosetting resin film should have the capacity of being precision debossed, e.g., stamped, with a tool at a relatively low temperature, such as temperatures as low as room temperature (~23.5°C.), with superior duplication of the pattern.
25 It is particularly desirable that the thin thermosetting resin film be amenable to a stamping procedure that debosses a grooved printed circuit pattern thereon with minimal loss of debossment precision of the grooved pattern. The film should be capable of
30 retaining the debossed pattern and the grooving through a cure cycle without flow out within the pattern, to produce a thermoset (i.e., cured) resin film that is employable for making a printed circuit board.

On the other hand, the thin thermosetting resin film may be subjected to flow into the grooves and cavities of a female tool, as defined above, to form a male replication of the female tool. Or the film may be shaped and stamped with a tool, subjecting the resin to temperatures sufficiently high enough to set the resin (e.g., by gelation, incipient gelation ("near-gelation") or cure) while in contact with the tool, thereby fixing a surface thereof to replicate the male or female image of the female or male surface, as the case may be. In this manner, the film of the invention is convertible into a male or female tool for making a PB by debossing another film having the same or similar composition, or the film can be used as a PB substrate.

The elements of the essentially nonconductive thermosetting resin film is that it is shapable. It has a thin uniform thickness. It contains a thermosetting resin that advances to a cured state without forming a significant volatile byproduct that will affect the quality of the cured film. It contains one or more flow control components that allows the film to be molded without edge flow constraints,¹ provides low flow of the film over a broad temperature range and retains a debossed image during debossment up to and through cure of the film. The film advances, under conditions leading to cure of the thermosetting resin, to a state of gelation (see IPC-TM-650 Method 2.3.18) or a condition that gives physical properties similar to the state of gelation (i.e., incipient gelation) at temperatures as low as about 20°C. to about 250°C., in

¹ This is to be contrasted with a conventional epoxy resin glass fiber fabric prepreg which on lamination results in flow of resin through the edges.

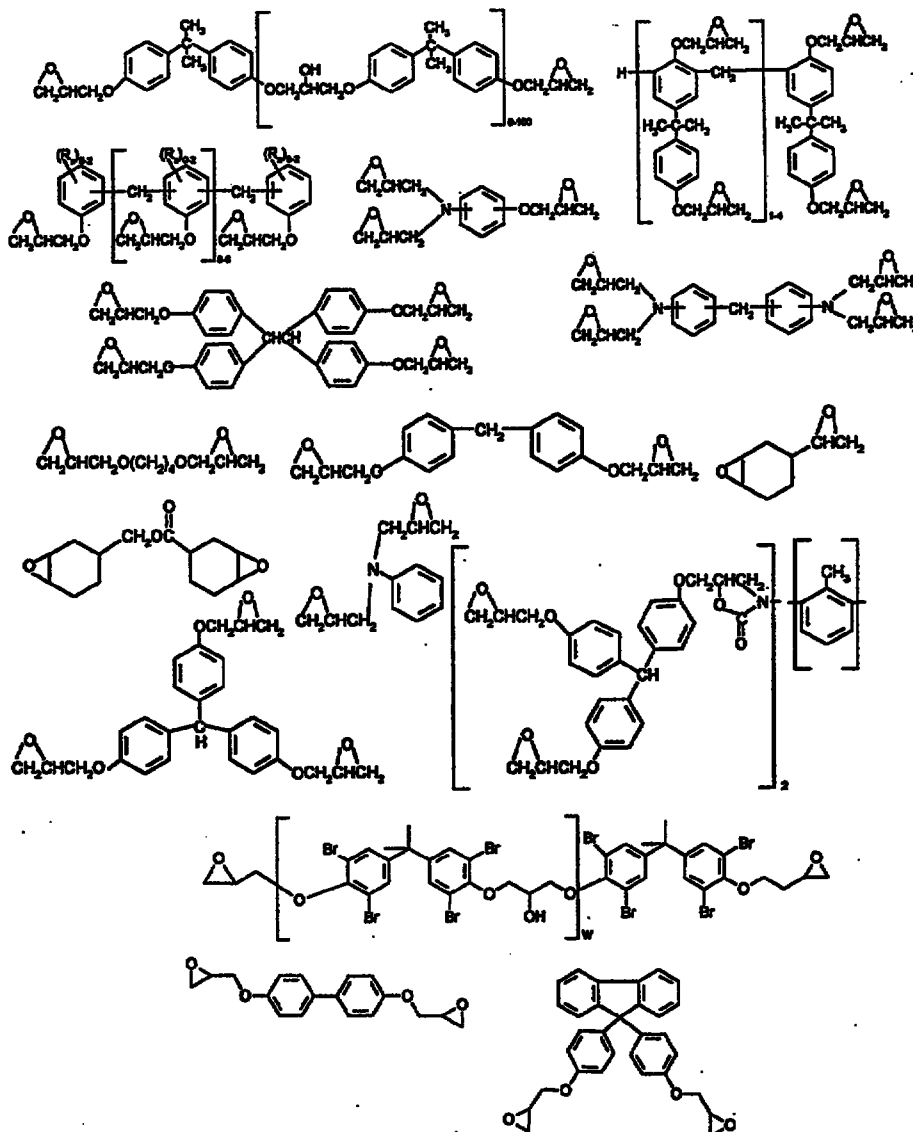
less than about 7 days and more than 1 second. Last but not least, the film exhibits a low dielectric constant (i.e., possesses the ability to resist the formation of an electric field within it) consistent with the requirements of a PB.

In another embodiment of the invention, the moldable, essentially nonconductive thermosetting resin film is metal platable and adheres to a conductive metal film. In particular, the film is metal platable and adhesively bondable to metal foil that can be used in the making of a stamping surface or for creating a conductive pathway on the stamped and cured resin film.

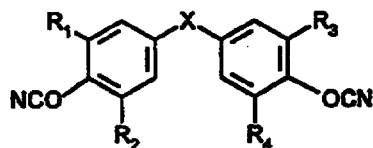
The Thermosetting Resin

The typical thermosetting resin is an A-stage resin. In some cases, it may be desirable to utilize a B-stage resin but in the typical case, such is done in combination with an A-stage resin. Such B-stage resin will affect the viscosity of the resin formulation but they are typically not relied on to achieve the level of thickening for the most effective operation of the invention.

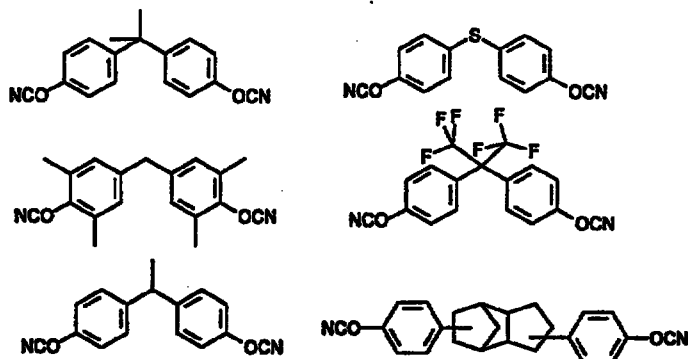
Epoxy systems curing in the range from 150°-400°F. (65.5°-204.4°C.) are common matrix resins for making thin film thermosetting resin products including the products of this invention. Matrix resin of bis-maleimide (BMI), phenolic, polyester, PMR-15 polyimide, cyanate ester resins and acetylene terminated resins may also be used. The most widely used matrix resins are the epoxy resins, and a wide variety are suitable for use in the practice of this invention. Illustrative of such epoxy resins are the following:



The epoxy resins may be modified up to 95 weight percent by including in the resin formulation bis-aryl cyanate esters, such as those of the formula:



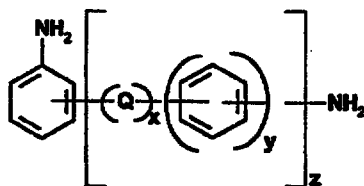
wherein X is a bisphenol linkage and R_{1,2,3} and 4 are ring substituents such as hydrogen, alkyl, aryl, and the like. Illustrative compounds are:



Another preferred resin is one that is totally the reaction product of one or more of the bis-aryl cyanate esters.

5 Catalysts and Hardeners

The epoxy resin systems contain epoxy curing agents to form solid, infusible products. For this purpose, epoxy curing agents that are acidic, neutral or alkaline may be used. Examples include, among others, amines hardeners, phenols, acid anhydrides, polyamides and Lewis acids and bases. Desirably, the epoxy resins of the invention are combined with hardeners that cure the resin to a thermoset condition. The preferred hardeners are amine compounds, ranging from di-cyandiamide, to ureas, to aliphatic and aromatic amines. Preferred are the aromatic amines encompassed by the formula:



wherein Q is one or more of a divalent group such as -SO₂-, -O-, -R_aR_bC-, -NH-, CO-, -CONH-, -OCONH-, and the like, Ra and Rb may each independently be one or more of hydrogen, phenyl, alkyl of 1 to about 4 carbon atoms, alkenyl of 2 to about 4 carbon atoms, fluorine, cycloalkyl of 3 to about 8 carbon atoms, and the like, x

may be 0 or 1, y may be 0 or 1 and is 1 when x is 1, and z may be 0 or a positive integer, typically not greater than about 5.

Another preferred class of hardeners are the aliphatic amines such as the alkyleneamines. Illustrative of suitable alkyleneamines are the following: monoethanolamine, ethylenediamine, N-(2-aminoethyl)ethanolamine, diethylenetriamine, piperazine, N-(2-aminoethyl)piperazine, triethylenetetramine, tetraethylenepentamine, pentaethylenehexamine, diaminoethylpiperazine, piperazinoethylethylenediamine, 4-aminoethyltriethylenetetramine, tetraethylenepentamine, aminoethylpiperazinoethylethylenediamine, piperazinoethyldiethylenetriamine, and the like.

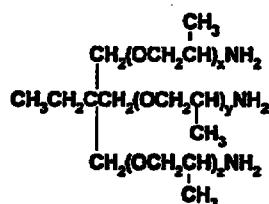
Another class of hardeners, which can also be used as extender of the epoxy resin, are the higher molecular weight poly(oxyalkylene)polyamines such as those of the following formulas:



where v is 2-40



where a+c is about 2
and b is 8-45.

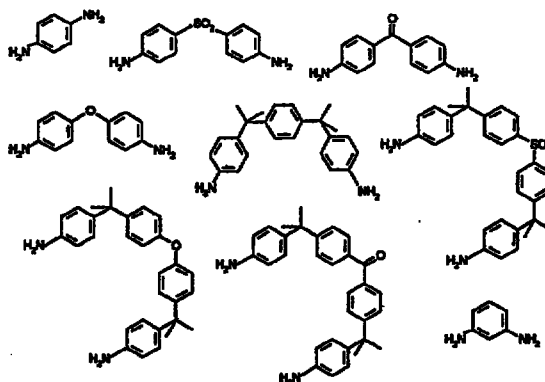


where x, y and z range from 2-40

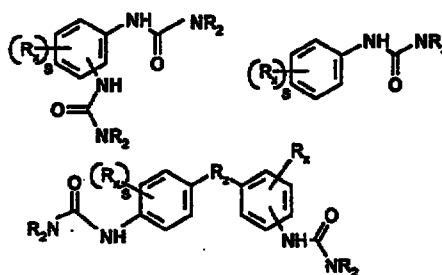


where m+n is about 82-88.

Preferred hardeners are diamines of the formula:



The hardener may be a monoamine such as aniline, para-aminophenol, and alkylated versions of them. Other desirable hardeners are the reaction products of dialkylamines, such as dimethylamine, diethylamine, methylethylamine, di-n-propylamine, and the like, with a variety of mono and diisocyanates to form mono and diureas. Any of the polyisocyanates listed below may be so reacted for use as a hardener. Specific illustration of useful hardeners are those encompassed by the following formulas and descriptions:



wherein R_y is a monovalent group; R_x is alkyl, halo, alkoxy, and the like; R_z is methylene, isopropylidene, ethylidene, or a covalent bond; and s is 0-4.

Preferred urea hardeners are those that are the reaction products of dimethylamine with mixtures of 80% 2,4-tolylene diisocyanate and 20% 2,6-tolylene diisocyanate, polymeric isocyanate, p-chlorophenylisocyanate, 3,4-dichlorophenylisocyanate or phenylisocyanate.

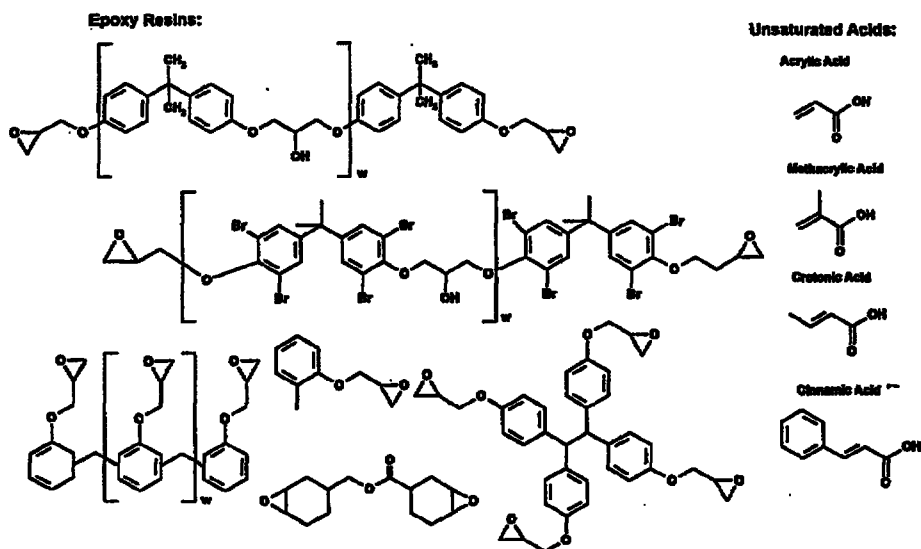
Accelerators may also be used and include imidazoles and substituted ureas. Examples include 2-ethyl-4-methylimidazole and p-chlorophenyl-1, 1-dimethyl urea.

5 The amount of the hardener employed is usually stoichiometric on the basis of one amine group per epoxy group in the resin. If the epoxide is a triepoxide and the hardener is a diamine, then the molar ratio of hardener to epoxide would typically be about
10 2.5/3 or 0.83. A typical formulation would have a weight ratio of epoxy resin to hardener of about 3/2 to about 4/1. Where any of the hardeners serve primarily as extenders of the epoxide resin, then the amount of the hardener in the typical case will be
15 less than that generally employed for hardening the epoxide. Mixtures of the above hardeners and with other hardeners are within the contemplation of this invention.

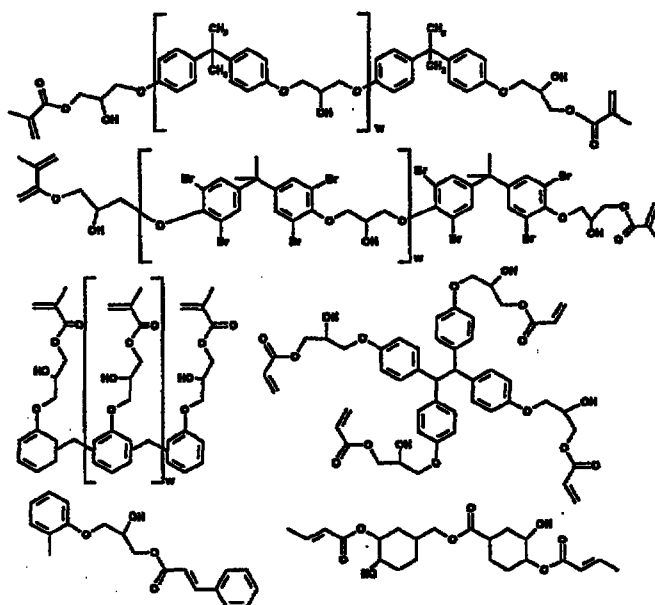
Other Useful Resins

20 As noted above, other reactive resin systems include the various thermosetting or thermosetting resins include the bismaleimide (BMI), phenolic, polyester (especially the unsaturated polyester resins typically used in SMC production), PMR-15 polyimide, bis-aryl cyanate esters and acetylene terminated resins are also
25 suitable.

30 A particularly desirable resin for this application is the vinyl ester resin. This class of resin is based on the reaction of unsaturated carboxylic acids and epoxy resins or epoxy compounds. Illustrative reactants in forming the vinyl esters are the following:



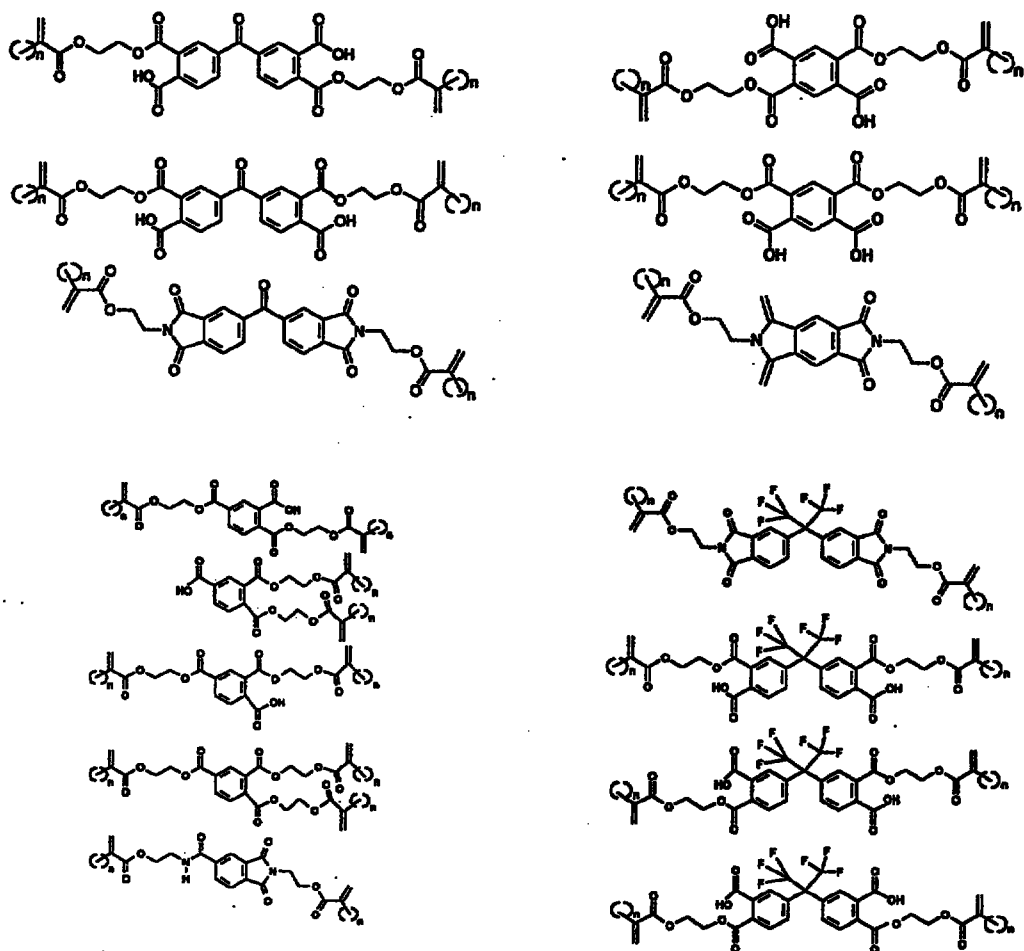
Typical of the vinyl esters are the following:



5 In the above formulae, w is a positive value of from about 1 to about 20, preferably from about 2 to about 10.

10 The vinyl ester resins may be used alone or in combination with monoethylenically unsaturated monomers, such as styrene, o-methylstyrene, m-methylstyrene, p-methylstyrene, ethylstyrene, α -vinyl-xylene, α -chlorostyrene, α -bromostyrene, vinylbenzylchloride, p-tert.-butylstyrene, methyl methacrylate, ethyl acrylate,

propyl acrylate, butyl acrylate, butyl methacrylate, propyl methacrylate, butyl methacrylate, lauryl acrylate, 2 - ethyl hexyl acrylate, ethyl methacrylate, and the like,



5 diethylene glycol dimethacrylate, 1,4-divinylbenzene, and the like. In the above, n is 0 or 1.

A number of vinyl ester resins require the use of solvents such as methyl ethyl ketone, acetone, toluene, and the like.

10 The vinyl esters may be cured by any free radical mechanism, such as by photoinitiation and/or by use of peroxidic compounds. A photoinitiator may be included in the formulation, as an optional ingredient. Light-initiated curing of the vinyl ester alone or with other

polymerizable materials involves photosensitization of light-sensitive compounds by ultraviolet or visible light, which, in turn, initiates polymerization of the resin materials. The photoinitiator may comprise a combination of a photosensitive ketone and a tertiary amine. Typical photosensitive ketones include benzophenone, acetophenone, thioxanthen-9-one, 9-fluorenone, anthraquinone, 4'-methoxyacetophenone, diethoxyacetophenone, biacetyl, 2,3-pentadione, benzyl, 4,4'-methoxybenzil, 4,4'-oxidibenzil, and 2,3-bornadione (dl camphroquinone). Typical tertiary amines include ethyl-4-dimethyl amino benzoate, ethyl-2-dimethyl amino benzoate, 4,4'-bis(dimethylamino) benzophenone, N-methyldiethanolamine, and dimethylaminobenzaldehyde. Any of the known photosensitizing system that can function effectively when exposed to light may substitute for the above-named compounds or combinations. The amount of the photoinitiator should be sufficient to initiate polymerization in a selected resin and complete it in depth within about half a minute when the resin composition is exposed to a visible-light output of at least 5,000 foot candles. In addition, any known free-radical scavenger (anti-oxidants) such as butylated hydroxytoluene can be used to scavenge small amounts of free radicals generated during extended shelf storage.

The curing of the vinyl ester is primarily effected by a thermal initiator, which is a typical thermal curing agent known in the art. Illustrative of these are benzoyl peroxide, dicumyl peroxide, methyl ethyl ketone peroxide, ditertiary butyl peroxide, tertiary butyl hydroperoxide, tertiary butyl perbenzoate, Luperox 118 (sold by Wallace and Tiernan, Lucidol Division, 1740 Military Road, Buffalo, NY 14240), cumene hydroperoxide, or other suitable peroxides may initiate polymerization of the polymerizable ethylenically unsaturated components of the primary coating. For example, Benzoyl peroxide may be used together with 2-hydroxyethyl-p-toluidine. It is common to combine metal salts such as metal naphthenates, e.g., cobalt naphthenate, and the like, with tertiary amines, such as dimethyl aniline, with the peroxidic catalyst.

The amount of catalyst is typically that amount that facilitates the cure within less than ten hours at a temperature greater than 25°C. Generally, the catalyst system will be less than about 10 weight percent of the resin formulation. As a
5 rule, the catalyst system will range from about 0.1 to about 8 weight percent of the resin formulation.

Thickening

As noted above, thickening of the resin in forming the film involves the combination in the resin formulation of --

- 10 i) one or more electronic grade filler;
- ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;
- iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin
15 matrix;
- iv) a thixotrope; and
- v) a mixture of two or more of i), ii), iii) and iv).

Illustrative of suitable electronic grade fillers are aluminum oxides including alumina trihydrate, coated aluminum
20 nitrate, silicon carbide, diamond, ground cured fiber reinforced thermoset resin, as well as a variety of thermoplastic and thermosetting fibers. The thermoplastic polymer used in forming these fibers may be made from condensation type polymers, such as nylon-6,6; nylon-6; nylon-4,6; polyester from

polyethylene terephthalate; KevlarTM polyaramide; polycarbonates (viz., poly (2,2-bis (1.4-oxyphenyl) propane carbonate)); polyarylates (viz., poly (2,2-bis(1.4-oxyphenyl) propane terephthalate); polyimides; 5 polyetherimides, such as UltemTM ²; polysulfones (see U.S. Patents No. 4,175,175 and 4,108,837), such as UdelTM and RadelTM A-400³; the polyethersulfones (see U.S. Patents Nos. 4,008,203, 4,175,175 and 4,108,837), such as VictrexTM ⁴; polyarylsulfones; polyarylamideimides, such as TorlonTM ⁵; and the acrylics and 10 modacrylic fibers; and the like. The thermoplastic polymer used in providing the thermoplastic polymer may also be made from condensation type polymers used in forming the film, such as nylon-6,6; nylon-6; nylon-4,6; polyester from polyethylene terephthalate; KevlarTM polyaramide; polycarbonates (viz., poly (2,2-bis (1.4-oxyphenyl) propane carbonate)); polyarylates (viz., poly (2,2-bis(1.4-oxyphenyl) propane terephthalate); polyimides; polyetherimides, such as UltemTM; 15 polysulfones (see U.S. Patents No. 4,175,175 and 4,108,837), such as UdelTM and RadelTM A-400; the polyethersulfones (see U.S. Patents Nos. 4,008,203, 4,175,175 and 4,108,837), such as VictrexTM; polyarylsulfones; polyarylamideimides, such as TorlonTM; and 20 the like. 25

A particularly preferred class of thermoplastic polymer for providing toughening and as a flow control

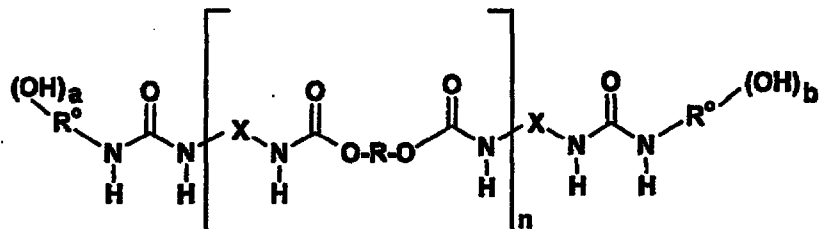
² Available from General Electric Company, Plastics Business Group, Pittsfield, MA.

³ Manufactured by Amoco Performance Products Inc.

⁴ Available from ICI Advanced Materials, Wilmington, DE 19897

⁵ Available from Amoco Chemical Company, Chicago, Ill.

aid for the thermosetting resin formulations are the polyurethanes of the formula:



wherein a and b are each 1, 2 or 3, n is at least 1, X is a divalent organic radical containing at least two carbon atoms in which the N's are bonded to different carbon atoms of X , R is an aliphatic polyester or polyalkylene oxide wherein

- the aliphatic polyester is a polyester of an alkylene diol and an aliphatic carboxylic acid, or a polycaprolactone polyol, and
- the alkylene group of the polyalkylene oxide contains on average greater than three carbon atoms and not greater than five carbon atoms, and

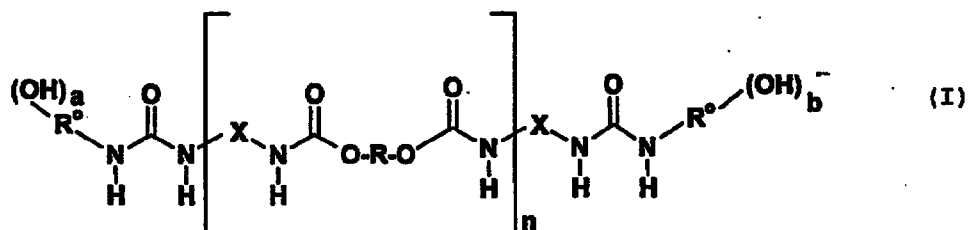
R° is an organic aromatic containing group in which the OH and N bonded to the R° group is bonded directly to different aromatic carbon atoms. Synergistic combinations of the polymer of formula (I) and other toughener polymers are useful in improving the toughening properties of the thermosetting resin formulations for making printed circuit board composites.

This invention includes the use in the thin film thermosetting resin formulation of a miscible or partially miscible linear polyurethane polymer containing phenolic hydroxyl functionality for reaction with a thermosetting resin comprising

- a linear polyurethane of recurring units containing linear ester or ether moieties or a combination of ester and ether moieties

- which are interbonded through urethane groups and
- uriedo bonded phenolic hydroxyl-containing terminal groups.

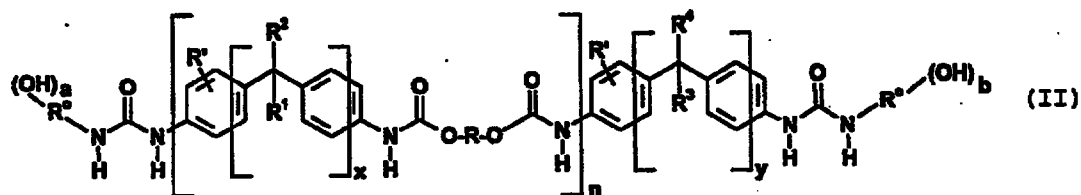
These linear polyurethane toughener polymers may
5 contain uriedo bonded phenolic hydroxyl-containing
terminal groups of the formula:



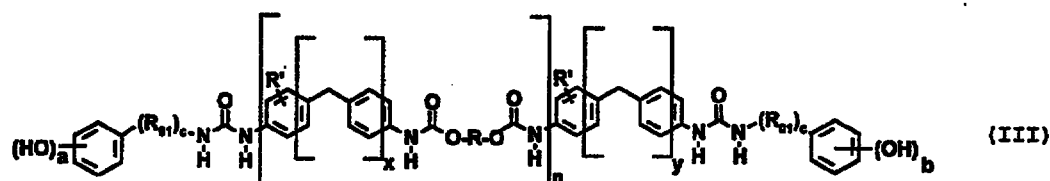
wherein a and b are each 1, 2 or 3, n is at least 1, each X is a divalent organic radical containing at least two carbon atoms in which the N's are bonded to different carbon atoms of X, R is an aliphatic polyester or polyalkylene oxide wherein

- the aliphatic polyester is a polyester of an alkylene diol and an aliphatic carboxylic acid, or a polycaprolactone polyol, and
- 15 • the alkylene group of the polyalkylene oxide contains on average greater than three carbon atoms and not greater than five carbon atoms, and

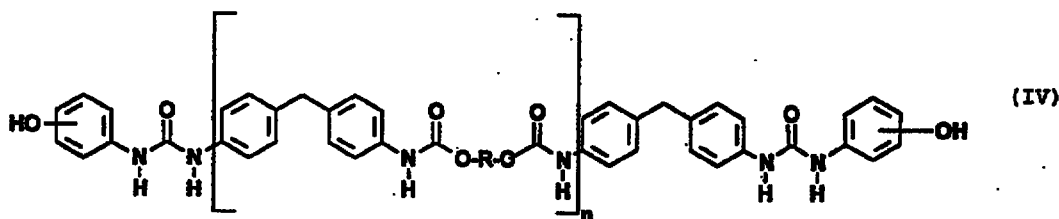
20 R^o is an organic aromatic containing group in which the OH and N bonded to the R^o group are bonded directly to different carbon atoms and the OH is bonded directly to an aromatic carbon atom. An improved version of the polymer of formula (I) is the polymer of formula (II).



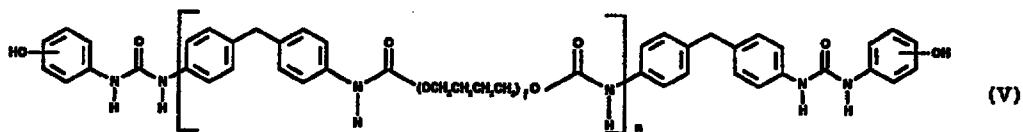
wherein x and y are 0 or 1, R' is hydrogen or alkyl of 1 to about 3 carbon atoms, and R^1 , R^2 , R^3 and R^4 are hydrogen, nitro, halogen or alkyl of 1 to about 4 carbon atoms. In a preferred embodiment of formula (I), the carbons to which the OH and N are bonded are separated from each other by at least one aromatic carbon atom. A more desirable embodiment is a toughener polymer of the formula:



In this embodiment, R_{01} is a divalent organic group and c is 0 or 1. In a preferred embodiment of the invention, with respect to the polymer of formula (II), x and y are each 1, R^1 , R^2 , R^3 and R^4 are hydrogen, a and b are 1 and n has a value such that the weight average molecular weight of the polymer is about 20,000 to about 120,000. Incorporating this preferred embodiment in formula (III), R_{01} is methylene or c is 0. In a further preferred embodiment is a polymer having the formula:



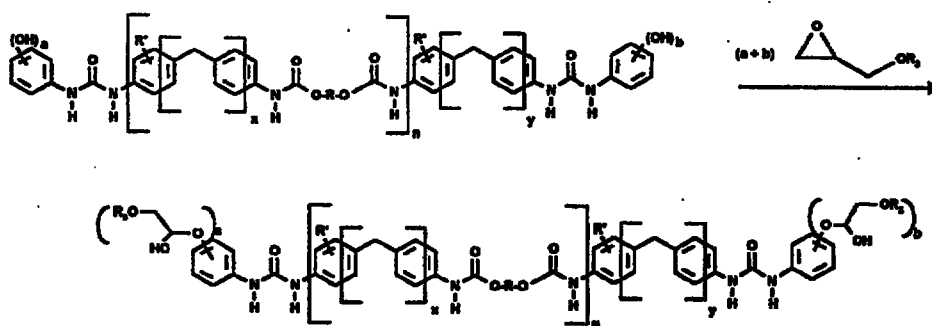
wherein n has a value such that the weight average molecular weight of the polymer is about 30,000 to about 110,000 and R is a polyalkylene oxide in which the alkylene groups thereof have an average value of about 3.5 to about 4.5 carbon atoms. A most preferred polyurethane polymer has the formula:



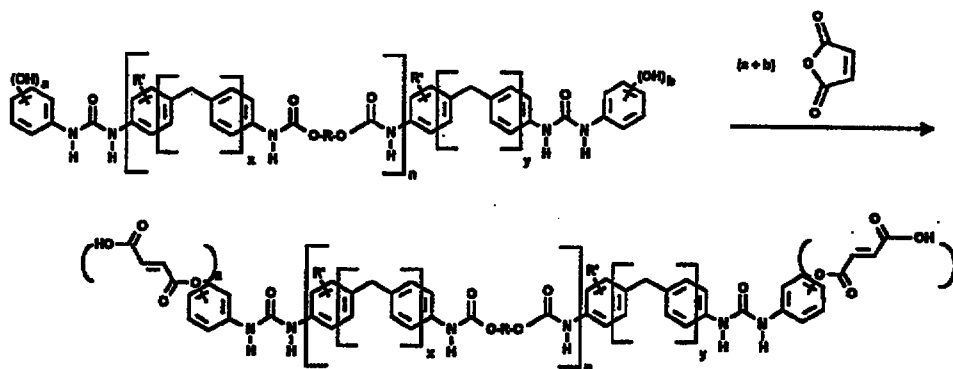
wherein n has a value such that the weight average molecular weight of the polymer is about 35,000 to about 100,000 and f has a value of at least 1, preferably from 1 to about 70, more preferably from about 4 to about 55, and most preferably from about 6 to about 42. The terminal hydroxyl groups may be in the ortho, meta or para positions, preferably in the para position.

A preferred polyurethane is one having a molecular weight from about 20,000 to about 120,000, preferably about 30,000 to about 110,000, and most preferably about 35,000 to about 100,000, formed by the reaction of a poly-1,4-butylene oxide diol having a molecular weight of from about 650 to about 5,000 with a stoichiometric excess of methylene diphenyldiisocyanate capped by reaction with o, m or p-amino phenol.

The polyurethane polymer suitable for use in the thermosetting resin film formulation can be a modification such as those made by the following reactions:



or



These polyurethane polymers are specially capped linear polyurethanes formed by the reaction of a diisocyanate of the formula $O=C=N-X-N=C=O$ with an alkylene diol of the formula $HO-R-OH$ in the molar ratio $(O=C-N-X-N=C=O/HO-R-OH)$ of >1 , such that the resulting polymer equals the value of n as defined above, followed by the reaction with aminophenolic compounds. Diisocyanates suitable for use in making the polyurethanes include the following:

bis (4-isocyanatocyclohexyl)methane	1,2-diisocyanatoethane
1,3-diisocyanatopropane	1,2-diisocyanatopropane
1,4-diisocyanatobutane	1,5-diisocyanatopentane
1,6-diisocyanatohexane	bis(3-isocyanatopropyl) ether
bis(3-isocyanatopropyl) sulfide	1,7-diisocyanatoheptane
1,5-diisocyanato-2,2-dimethylpentane	1,6-diisocyanato-3-methoxyhexane
1,8-diisocyanatooctane	1,5-diisocyanato-2,2,4-trimethylpentane
1,9-diisocyanatononane	1,10-diisocyanatopropyl) ether of 1,4-butylene glycol
1,11-diisocyanatoundecane	1,12-diisocyanatododecane
bis(isocyanatohexyl) sulfide	1,4-diisocyanatobenzene
2,4-diisocyanatotolylene	2,6-diisocyanatotolylene
1,3-diisocyanato-o-xylene	1,3-diisocyanato-m-xylene
1,3-diisocyanato-p-xylene	2,4-diisocyanato-1-chlorobenzene
2,4-diisocyanato-1-nitrobenzene	2,5-diisocyanato-1-nitrobenzene

2,2-bis(4-isocyanato)phenylpropane	bis(4-isocyanato)phenylethane
4,4'-diphenylmethylenediisocyanate	3,3'-diphenyl-methylenediisocyanate
polymethylene poly(phenyleneisocyanates)	isophorone diisocyanate

and mixtures thereof.

The preferred polyisocyanates are TDI, i.e., the mixture of 80% 2,4-tolylenediisocyanate and 20% 2,6-tolylenediisocyanate, or the individual monomer 2,4-tolylenediisocyanate (2,4-TDI) and 2,6-tolylenediisocyanate (2,6-TDI) and MDI, i.e., 4,4'-diphenylmethylenediisocyanate and 3,3'-diphenylmethylenediisocyanate, or the individual monomer 4,4'-diphenylmethylenediisocyanate (4,4'-MDI) or 3,3'-diphenylmethylenediisocyanate (3,3'-MDI).

The polyalkylene ether or oxide diol comprises a divalent alkylene oxide moiety wherein the alkylene groups contain, on average, greater than three carbon atoms and not greater than five carbon atoms. Typically, they are based on ethylene oxide, 1,2-propylene oxide, 1,3-propylene oxide, 1,2-butylene oxide, 1,3-butylene oxide, 1,4-butylene oxide, 1,2-pentylene oxide, 1,3-pentylene oxide, 1,4-pentylene oxide, 1,5-pentylene oxide, 1,2-hexylene oxide, generally polymerized alone when the alkylene group contains greater than 3 carbon atoms, or as mixtures, so as to form a number average alkylene carbon content greater than about 3 and as high as about 5, preferably greater than 3.5 and as high as about 4.5. Many types of alkylene oxide diols are available for urethane production but all of those that have an average alkylene below about 3.5 have too high water absorption properties for use in high performance

adhesive applications. Such exclude the polyethylene oxide diol homo-oligomers and the polypropylene oxide diol homo-oligomers from consideration in forming the polyurethane tougheners.

5 All of the polyalkylene oxide diols used in making the polyurethane tougheners/flow control aids are prepolymers of the alkylene oxide(s), created by the polymerization of the monomeric alkylene oxide. Such prepolymer formation as well as their reactions to
10 form polyurethanes is notoriously well known. Of the prepolymers, a preferred one is based on the polymerization of 1,4-butylen oxide (i.e., tetrahydrofuran) to a molecular weight of from about 650 to about 5,000. Such prepolymers are commercially
15 available from DuPont under the name Terathane®. Terathanes® range in molecular weights as low as about 650 to as high as about 2900, as well as molecular weight versions of about 1000 and 2000. Higher and lower molecular weight versions are also available.
20 Such prepolymers provide low water absorption, flexible molecular structure, hydrolytic stability, and commercial availability at a moderate cost. Terathanes® have the formula $\text{HO}(\text{CH}_2\text{CH}_2\text{CH}_2\text{CH}_2\text{O})_t\text{H}$ where t has a value of about 8-9 to about 40, though higher and lower values are available, and such oligomers
25 could be used in making the polyurethanes.

Terathanes® have been widely recommended for use in making polyurethanes by DuPont. For example, they have been recommended by DuPont for use in forming
30 soft segments in polyurethanes. When used with TDI, DuPont advises that amines such as 4,4'-methylene-bis(2-chloroaniline) are favored as chain extenders or curatives. If 4,4'-MDI is the chain extender, DuPont advises that 1,4-butanediol is the favored chain

extender. However, this invention does not rely on other monomers as chain extenders or curatives though chain extenders can be employed to raise the molecular weight of lower polyurethane prepolymers prior to the capping step in making the polyurethanes.

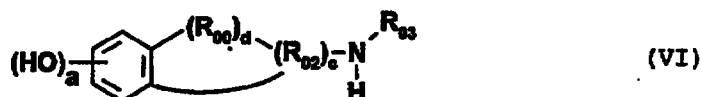
The polyester diols useful in making the polyurethanes are based on the reaction products of an aliphatic dicarboxylic acid derivative (such as the acid halide or ester) and an aliphatic diol derived from an polyalkylene oxide diol such as an alkylene glycol of 2 to about 5 carbon atoms, or based on the reaction of ϵ -caprolactone with a starter organic diol. These polyester diols are commercially available materials. They are typically less hydrolytically stable than the aforesaid polyalkylene oxide diols. Those that are desirable in the practice of the invention are those that possess low water absorption, flexible molecular structure, hydrolytic stability, and commercial availability at a moderate cost.

The linear polyester resins may be reaction products of saturated and unsaturated aliphatic dicarboxylic acids, such as malonic acid, succinic acid, adipic acid, maleic acid, fumaric acid, hexahydro or tetrahydrophthalic acid, "dimer" acid (dimerized fatty acids), and their respected anhydrides (where chemically possible), acid halides, and esters, with organic diols. The polyester may include in the reaction a minor amount, typically not more than 20 mol %, preferably not more than 10 mol %, of the acid component of the polyester, of an aromatic dicarboxylic acid such as o-phthalic acid or anhydride, isophthalic acid, terephthalic acid, their respected anhydrides (where chemically possible), acid halides, and esters.

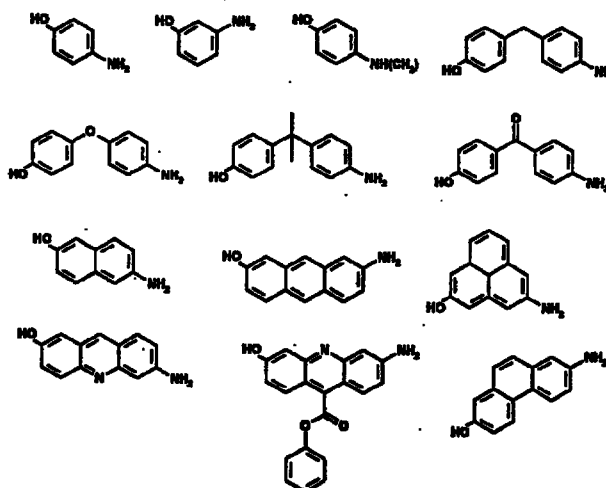
In addition to the above polyesters one may also use dicyclopentadiene modified unsaturated polyesters like those described in U.S. Patent Nos. 3,986,922 and 3,883,612, so long as the polyester is linear. The organic diol employed to produce the polyester may include the alkylene glycols such as ethylene glycol, propylene glycol, butylene glycol, dipropylene glycol, diethylene glycol, neopentyl glycol, and the like, and the polyalkylene oxide glycols such as triglyme (b.p. 216°C.), tetraglyme (b.p. 276°C.), tripropylene glycol, tetrapropylene glycol, and the like.

Chain termination of the linear polyalkylene oxide or polyester polyurethanes is effected by reacting more than one mole of the diisocyanate for each mole of the polyalkylene oxide diol and/or polyester diol. The amount of the stoichiometric excess of the diisocyanate will determine the degree of polymerization (n) of the polyurethane. A stoichiometric amount of the diisocyanate to the diol is 1 mole of each. If the reaction is conducted under anhydrous conditions, using an excess of diisocyanate over the stoichiometric amount results in a polymer that is chain terminated with isocyanato groups at each end. If any water is present in the polyurethane formation step, then stoichiometry should take that into account, because water will generate more near-terminal residing urea, as well as terminating isocyanato groups appended thereto. The level of excess diisocyanate will determine the degree of polymerization and thus determine the value of n in the above formulas. Such an isocyanato-terminated polymer is not a thermally or chemically stable polymer.

The hydroxy aromatic amino compound for terminating the isocyanato containing polyurethane is preferably a structure of the formula:



wherein the combination of R_{00} and R_{02} is equivalent to R^0 and R_{01} defined above, and in particular, R_{00} may be a covalent bond or a divalent non-aromatic group such as alkylene, alkylidene, oxygen, carbonyl, sulfone, and the like, d is 0 or 1 and when it is 1, the hatched line designating a fused ring bond is nonexistent, and when d is 0, the hatched line may exist as a fused ring bond to R_{02} . R_{02} is aryl, polyaryl, fused ring aryl, polyfused ring aryl, cycloalkyl and the like, and c is 0 or 1. When d is 1, c is 1, and when d is 0, c may be 0 or 1. R_{03} is hydrogen, or alkyl of 1 to about 14 carbon atoms. Illustrative examples of suitable amines are the following:



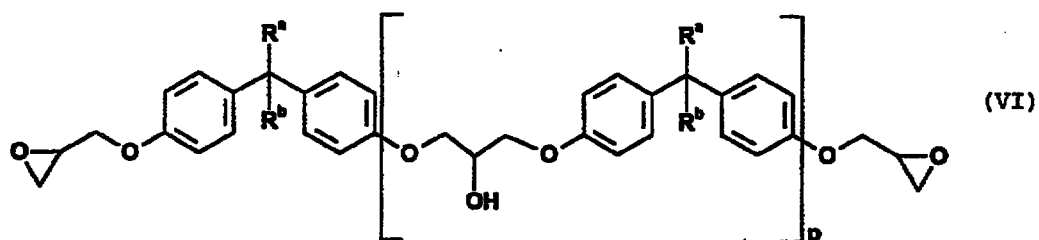
The aminophenols, p, m or o-aminophenol, prove to be effective terminating molecules for the isocyanato capped polyurethanes. Solubility or a low melting point gives the meta product some advantage but the p-

aminophenol dissolves readily in the toughener polymer - epoxide reaction system at the temperatures generally used (80-120°C). The low molecular weight of these aminophenols (109.1) means that relatively small amounts can be used for termination, solubility is high, the termination reaction is rapid, governed mostly by the time required to get good dispersion in the high viscosity system. The powdered amino phenol can be added directly to the reaction mixture or more desirably can be powdered, mixed with a small portion of the low oligomer epoxide resin diluent, discussed below, and then added. Measurement of the IR absorption ratio of the isocyanate group 2240 cm^{-1} peak to the 2840 cm^{-1} -CH peak can be used to ensure that termination is complete.

During the polymerization of diisocyanates with the hydroxy terminated alkylene oxide or polyester based materials, high molecular weights are attained (~20K-~120K, more typically in the range of about 30K to about 100K). As a result, viscosities became very high and at rational reaction temperatures (~50-170°C, preferably from about 80°C.-120°C.) stirring in laboratory or production equipment can become difficult. Use of a solvent as a diluent (e.g., methylethylketone (MEK), tetrahydrofuran (THF), and the like) of the reactants and the reaction products, though usable in making the polymers of the invention, adds the problem of its subsequent removal with a concomitant increase in production cost. Advantage is taken of the very low reactivity of hydroxyl groups with epoxide groups (unless catalyzed) and also the low reactivity of isocyanate groups with epoxide groups (unless the complex formation of oxazolidone is deliberately forced). Therefore, oligomer-free and

thus secondary hydroxyl-free, epoxide resins can be used as unreactive diluents during the polymer formation. Such epoxide resins are subsequently compatible with formulation needs in future adhesive systems. For this dilution during reaction, epoxides as free as possible from oligomers should be used. Shell's Epon® 825 (the diglycidyl ether of bisphenol A) has been successfully used as a diluent even although the small amount of oligomer present (5%) did show some reaction. At 1/1 ratio to total derived polymer, Epon® 825 gave polymer products easily stirred at needed production temperatures and at that level should meet most subsequent formulation needs. D.E.N.® 332 from Dow Chemical should also be suitable. The Bis F resins, such as Epiclon® 830S, if distilled to eliminate oligomers, could also be used.

Illustrative of suitable diluents are epoxy monomers and dimers of the following formula:



wherein R^a and R^b are each hydrogen, alkyl of 1-3 carbon atoms or phenyl, preferably alkyl such as methyl, and p has a value of 0 to <1 , preferably less than about 0.2. Most preferably, p is equal to 0.

The reaction conditions for forming the polyurethane from the diisocyanate and the diol is a temperature of about 50°C. to about 200°C. with mixing in the presence of a diluent, such as a conventional solvent, as indicated above, or the reactive diluent comprising the epoxy monomeric resin indicated above. The reaction should be carried out in the absence of

added water, and anhydrous conditions are preferred. Conditions that remove water from the reactants before reaction and during reaction are desirable. No special catalysts are needed to effect the reaction but a catalyst that does not adversely affect the reactions can be employed. Catalysts are needed in polymerization reactions using aliphatic isocyanates.

The foregoing polyurethanes and their manufacture are described in commonly assigned copending U.S. Application S.N. 08/349,876, filed December 6, 1994.

Another class of flow control aid thixotropic agents and/or elastomer-type polymers that provide discrete elastomer phases (second phases) in the thermosetting resin matrix. Certain of these materials may reduce, to some finite degree, the crosslinking density of the thermoset resin (C-stage). Many of these materials introduce very favorable properties to the resulting thermoset resin. For example, a particularly desirable material for this purpose, is an elastomeric polymer containing soft and hard segments, the hard segments acting like or forming on processing, crosslinking of the elastomeric type. Some of these elastomeric types contain functional end groups that allow it to couple with complementary functional monomers or polymers to form the desired elastomer *in situ* of the thermosetting resin and render it non-pourable and tacky, while toughening the cured resin. As a class, these elastomeric polymers act or are crosslinked yet are thermoprocessable, which when discretely provided in the matrix resin render the resin non-pourable and tacky, and also toughens it.

One class of suitable elastomer-type thermoplastic ABS (acrylonitrile-1,4-butadiene-styrene) block copolymers that are typically used as modifiers of other

resin systems. They are characterized as having a wide range of properties though the preferred systems of the invention utilize copolymers that are high rubber types that, when compared to other copolymers of this type, have a relatively low tensile strength, low tensile modulus, higher impact resistance, low hardness and heat deflection temperature.

Another elastomer that is found desirable are the carboxyl and amine terminated liquid butadiene acrylonitrile copolymers. Such copolymers may contain pendant carboxyl groups in the interior of the polymer structure through the inclusion of methacrylic or acrylic acid in the polymerization or through the hydrolysis of some of the pendant nitrile units. Such polymers react with the epoxy resin and as a result, the epoxy forms the hard segment generating the elastomer properties.

Another class of block thermoplastic elastomers is Kraton®, available from Shell Chemical Company. These thermoplastic rubber polymers possess usable thermoplastic properties. They can be softened and they flow under heat and pressure. They then recover their structures on cooling. The chemical make-up are of three discrete blocks of the linear or A-B-A type. They are available as styrene-butadiene-styrene (S-B-S) block copolymers, styrene-isoprene-styrene (S-B-S) block copolymers and styrene-ethylene/butylene-styrene (S-EB-S) block copolymers. They are characterized by styrene polymer endblocks and an elastomeric midblock. After processing, the polystyrene endblocks physically crosslink, locking the rubber network in place. This physical crosslinking is reversible on heating.

Another series of the Kraton® thermoplastic rubbers are the diblock polymers in which one block is a hard

thermoplastic and the other is a saturated soft elastomer. Illustrative of this series is Kraton® G 1701, a diblock polymer of a hard polystyrene block and a saturated, soft poly(ethylene-propylene) block.

- 5 Other rubbers or elastomers include: (a) homopolymers or copolymers of conjugated dienes having a weight average molecular weight of 30,000 to 400,000 or higher as described in U.S. Pat. No. 4,020,036, in which the conjugated dienes contain from 4-11 carbon
10 atoms per molecule such as 1,3-butadiene, isoprene, and the like; (b) epihalohydrin homopolymers, a copolymer of two or more epihalohydrin monomer, or a copolymer of an epihalohydrin monomer(s) with an oxide monomer(s) having a number average molecular weight
15 (M_n) which varies from about 800 to about 50,000, as described in U.S. Pat. No. 4,101,604; (c) chloroprene polymers including homopolymers of chloroprene and copolymers of chloroprene with sulfur and/or with at least one copolymerizable organic monomer wherein
20 chloroprene constitutes at least 50 weight percent of the organic monomer make-up of the copolymer as described in U.S. Pat. No. 4,161,471; (d) hydrocarbon polymers including ethylene/propylene dipolymers and copolymers of ethylene/propylene and at least one non-
25 conjugated diene, such as ethylene/ propylene/ hexadiene/ norbornadiene, as described in U.S. Pat. No. 4,161,471; (e) conjugated diene butyl elastomers, such as copolymers consisting of from 85 to 99.5% by weight of a C_4 - C_5 isolefin combined with 15 to 0.5% by weight
30 of a conjugated multi-olefin having 4 to 14 carbon atoms, copolymers of isobutylene and isoprene where a major portion of the isoprene units combined therein have conjugated diene unsaturation, as described in U.S. Pat. No. 4,160,759.

Specific illustrations of suitable elastomeric polymers are the following:

1. Hycar™ CTBN liquid reactive rubbers, carboxyl terminated butadiene-acrylonitrile copolymers sold by B. F. Goodrich.
2. Hycar™ CTBNX, similar to CTBN except that they contain internal pendant carboxyl groups, also supplied by B. F. Goodrich.
3. Hycar™ ATBN, amine terminated butadiene-acrylonitrile copolymers sold by B. F. Goodrich.
4. K 1102-28:72 styrene:butadiene linear SBS polymer, available from Shell Chemical Company as Kraton® 1102.
5. KDX 1118-30:70 styrene:butadiene copolymer containing 20% SBS triblock and 80% SB diblock, available from Shell Chemical Company as Kraton® DX 1118.
6. KG 1657-14:86 styrene:ethylene-butylene:styrene copolymer available from Shell Chemical Company as Kraton® G1657.
7. S 840 A-Stereospecific 43:57 styrene-butadiene SB rubber available from Firestone Synthetic Rubber & Latex Company as Stereon® 840A.
8. SBR 1006-random 23.5:76.5 styrene:butadiene SB block copolymer rubber available from Goodrich Chemical Company as Ameripol® 1006.
9. SBR 1502-Random 23.5:77.5 styrene:butadiene rubber available from Hules Mexicanos, or from Goodrich Rubber Company as Ameripol™ 1502.
10. Blendex™ modifier resins (e.g., 305, 310, 311, 336, 338 and 405) - ABS polymers sold by General Electric. Different varieties are available and their suitability depends on the properties sought.

Additional flow reductions are provided by thixotropic agents such as fumed silica. Illustrative of thixotropic agents are high surface area fumed silicas and organosilyl blocked fumed silicas, and the like.

5 The thin film may be characterized as non-pourable. Optionally, the film may be tacky as well. This condition can be achieved in a number of ways. Many thermosetting resins are solids at about 23°C. and many of them are liquids at this temperature. Both
10 kinds of resins can be made fluid non-pourable and tacky. For example, a resin that is solid and a resin that is liquid can be combined to form a mixed resin system that is non-pourable and tacky. In addition, a
15 solid or liquid thermosetting resin can have incorporated in it a variety of diverse materials that will render the resin fluid non-pourable at conventional handling temperature conditions and fluid non-pourable and tacky at room temperature (about 15-37°C.). Conventional handling temperatures are defined as a temperature of between about -20°C. to about 43°C.⁶
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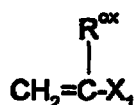
 Though the *in situ*-expandable thermoplastic particles or the solid chemical blowing agent will render a liquid thermosetting resin more viscous, they alone are not effective for making the film non-pourable.
25 If the thermosetting resin is solid, it can be calendered into a film by melting the resin with heat under conditions that avoid condensation or addition of the resin to a thermoset condition (C-stage). If the resin is a liquid, it can be blended with thixotropic
30 agents, other solid resins and/or liquid or thermo-

⁶ This range reflects the fact that material handling can require low temperature storage to preclude premature reaction of the thermosetting resin system and relatively high temperatures because the film may be used on a hot factory floor.

plastic elastomeric modifiers to convert the resin from a liquid to a non-pourable and tacky material.

5 The thermoplastic polymer used in forming the *in situ*-expandable thermoplastic particles are readily prepared from a wide variety of materials. A number of patents refer to their manufacture. For example, U.S. Patent No. 3,615,972 describes their preparation by polymerizing the monomer of an aqueous dispersion of (1) organic monomeric materials suitable for polymerization to a thermoplastic resinous material having the desired physical properties, (2) a liquid blowing or raising agent which exerts a little solvent action on the resulting polymer, and in a quantity in excess of that which is soluble in the polymer, and (3) a dispersion stabilizing material that is utilized to maintain the dispersion. The resulting solid spherical particles have a quantity of the liquid-blowing agent encapsulated in them as a distinct and separate phase.

20 The thermoplastic polymers are formed by the polymerization of one or more of a variety of different types of alkenyl monomers, such as those of the formula:



25 to form homopolymers or copolymers, such as random or ordered (including block) copolymers. In the above formula, R^{ox} may be hydrogen, alkyl, such as methyl, ethyl and the like, or halogen, such as chlorine, fluorine, bromine or iodine, and X_1 may be an aromatic containing moiety bonded via an aromatic carbon atom, a carbonyl oxy ester moiety, halogen, cyano, oxycarbonyl ester, carboxyl, and the like. Illustrative of

30

these monomers are those in which X_1 is aromatic containing, such as styrene, o-methylstyrene, m-methylstyrene, p-methylstyrene, ethylstyrene, α -vinylxylene, α -chlorostyrene, α -bromostyrene, vinylbenzylchloride, p-tert.-butylstyrene, and the like. Also illustrative of these monomers are those in which X_1 is a carbonyl oxy ester moiety to form acrylate monomers alone or in combination with the alkenyl aromatic monomers may also be utilized. Such acrylate-type monomers include methyl methacrylate, ethyl acrylate, propyl acrylate, butyl acrylate, butyl methacrylate, propyl methacrylate, butyl methacrylate, lauryl acrylate, 2 - ethyl hexyl acrylate, ethyl methacrylate, and the like. X_1 and R^{ox} may be a halogen, such as chlorine, fluorine, bromine and iodine, thereby to encompass the formation of copolymers of vinyl chloride and vinylidene chloride, acrylonitrile with vinyl chloride, vinyl bromide, and similar halogenated vinyl compounds. X_1 may be a cyano group and this includes polymers of acrylonitrile and methacrylonitrile. X_1 may be an oxycarbonyl ester, such as the vinyl ester, e.g., vinyl acetate, vinyl butyrate, vinyl stearate, vinyl laurate, vinyl myristate, vinyl propionate, and the like, are suitable polymeric components. One may also employ for specific purposes ethylenically unsaturated copolymerizable acids such as acrylic acid, methacrylic acid, itaconic acid, citraconic acid, maleic acid, fumaric acid, vinylbenzoic acid, and the like.

The thermoplastic polymers may also include copolymers (of the random or ordered varieties, especially blocked copolymers) of the monomers described above with a variety of hydrocarbon monomers, such as propylene, butene, and one or more dienes, such as:

- straight chain acyclic dienes such as: 1,4-hexadiene, 1,6-octadiene, and the like;
- branched chain acyclic dienes such as: 5-methyl-1,4-hexadiene, 3,7-dimethyl-1,6-octadiene, 3,7-dimethyl-1,7-octadiene and the mixed isomers of dihydro-myrcene, dihydroocinenene, and the like;
- single ring alicyclic dienes such as: 1,4-cyclohexadiene, 1,5-cyclooctadiene, 1,5-cyclododecadiene, and the like;
- multi-ring alicyclic fused and bridged ring dienes such as: tetrahydroindene, methyltetrahydroindene, dicyclopentadiene, bicyclo-(2,2,1)-hepta-2,5-diene, alkenyl, alkylidene, cycloalkenyl and cycloalkylidene norbornenes such as 5-methylene-2-norbornene (MNB), 5-ethylidene-2-norbornene (ENB), 5-propyl-2-norbornene, 5-isopropylidene-2-norbornene, 5-(4-cyclopentenyl)-2-norbornene, 5-cyclohexylidene-2-norbornene, and the like.

The thermoplastic polymer used in forming the in situ-expandable thermoplastic particles may also be made from condensation type polymers, such as nylon-6,6; nylon-6; nylon-4,6; polyester from polyethylene terephthalate; Kevlar™ polyaramide; polycarbonates (viz., poly (2,2-bis (1,4-oxyphenyl) propane carbonate)); polyarylates (viz., poly (2,2-bis(1,4-oxyphenyl) propane terephthalate)); polyimides; polyetherimides, such as Ultem™; polysulfones (see U.S. Patents No. 4,175,175 and 4,108,837), such as Udel™ and Radel™ A-400, the polyethersulfones (see U.S. Patents Nos. 4,008,203, 4,175,175 and 4,108,837), such as Victrex™; polyarylsulfones; polyarylamideimides, such as Torlon™; and the like.

A wide variety of blowing or raising agents may be incorporated within the polymerization system. They can be volatile fluid-forming agents such as aliphatic hydrocarbons including ethane, ethylene, propane, propylene, butene, isobutylene, neopentane, acetylene, hexane, heptane, or mixtures of one or more such aliphatic hydrocarbons having a molecular weight of at least 26 and a boiling point below the range of the softening point of the resinous material when saturated with the particular blowing agent utilized.

Other suitable fluid-forming agents are the chlorofluorocarbons such as those described in U.S. 3,615,972 (column 4, lines 21-30) and tetraalkyl silanes such as tetramethyl silane, trimethylethyl silane, trimethylisopropyl silane and trimethyl-n-propyl silane. As pointed out in this patent, the boiling point of such foaming agents at atmospheric pressure should be about the same temperature range or lower than the softening point of the resinous material employed.

Blowing agents such as the Freons®, such as trichlorofluoromethane, hydrocarbons such as n-pentane, i-pentane, neo-pentane, butane, i-butane, azodicarbonamide are commonly suggested blowing agents found in these types of *in situ*-expandable particles. Typically, the unexpanded particles contain from about 3 to about 40 weight % blowing agent.

As pointed out in U.S. Patent No. 4,397,799, patented August 9, 1983, the particle size of the unexpanded particles, as well as the expanded microspheres can vary widely. Particle sizes for the unexpanded particles can range, for example, from about 1 μ m to about 1 mm, preferably from about 2 μ m to about 0.5 mm. One version of *in situ*-expandable particles is

sold under the name Expancel®, by Nobel Industries Sweden, Sundsvall, Sweden (U.S. address: Marietta, GA 30062). They range in unexpanded particle size from about 5 μm to about 50 μm . The particle diameters expand 2 to 5 times.

Preferably, the *in situ*-expandable particles used have a mixed particle size of wide spread to achieve the best packing, on expansion, in the syntactic molded foam. A particularly preferred *in situ*-expandable particle is Expancel® 091 DU, which is believed to be a terpolymer of vinylidene chloride, acrylonitrile and methacrylonitrile containing 10-18 weight % isopentane, and possesses the following properties: average unexpanded particle size of about 12 μm with a spread of about 5-50 μm ; true density (expanded in water at 100°C., kg/m^3), <20; TMA - T(start) °C., 125-130; T(max) °C., ~183; TMA-density, kg/m^3 , <17.

The chemical blowing agent particles (with a particle size ranging from about 1 μm to about 1 mm, preferably from about 2 μm to about 0.5 mm) that can be incorporated are inorganic and organic solid compositions that typically decompose at a particular temperature to generate a volatile (gas) component that causes microcell formation in the thermosetting matrix resin. Typical inorganic blowing agents include the ammonium carbonates and bicarbonates, alkali metal carbonates and bicarbonates such as lithium carbonate, sodium carbonate, potassium carbonate, rubidium carbonate, cesium carbonate, lithium bicarbonate, sodium bicarbonate, potassium bicarbonate, rubidium bicarbonate, cesium bicarbonate, mixture of the carbonates and bicarbonates as well as mixtures of the alkali metal form of the carbonates and bicarbonates. These car-

bonates and bicarbonates can be made to decompose at lower temperatures by incorporating organic carboxylic acids and acid anhydrides blowing agent accelerators into the formulation. Suitable organic carboxylic acids and anhydrides are citric acid, acetic acid and anhydride, maleic anhydride, There are a variety of chemical blowing agents sold under the name Celogen™ (Naugatuck Chemical Division of U.S. Rubber Company (Uniroyal)) that include toluene sulfonyl hydrazide, toluene sulfonyl semicarbazide, 5-phenyl tetraazole, azodicarbonamide, and the like, that are excellent chemical blowing agents suitable for the purposes of the invention. The chemical blowing agents may be employed in the formulations of the invention in amounts ranging from about 0.1 to about 3 parts by weight, preferably from about 0.5 to 2.0 parts by weight, of the thermosetting resin formulation.

Low Profile Additives

There may be incorporated into the thermosetting resin formulation certain thermoplastic materials known in the field as low profile additives. These can be polymers of vinyl acetate, acrylics, saturated polyesters, polyurethanes, styrene-butadiene and similarly used materials.

Suitable thermoplastic vinyl acetate polymer low profile additives are thermoplastic poly(vinyl acetate) homopolymers and copolymers containing at least 5 weight percent vinyl acetate. Such polymers include, for example, vinyl acetate homopolymer; carboxylated vinyl acetate polymers include copolymers of vinyl acetate and ethylenically unsaturated carboxylic acids, such as acrylic acid, methacrylic acid, maleic acid, fumaric acid, itaconic acid and the like or anhydrides such as maleic anhydride; vinyl acetate/vinyl chloride/maleic acid terpolymer, and the like. Reference is made to

U.S. Patent Nos. 3,718,714 and 4,284,736 and British Patent No. 1,361,841 for descriptions of some of the suitable vinyl acetate polymer low profile additives. The useful vinyl acetate polymer low profile additives ordinarily have molecular weights within the range of from about 25,000 to about 175,000. Suitable polyvinyl acetate low profile additives are LP-40 and LP-40A that are sold by Union Carbide Chemical & Plastics Corp., Danbury, CT.

Suitable thermoplastic saturated polyester low profile additives are, in general, low molecular weight saturated polymers of polymerizable linear and/or cyclic esters and carboxylated saturated polymers and said polymerizable esters having at least one carboxyl group per molecule. Polymer of linear and/or cyclic esters including carboxylated polymers having an average of at least one carboxyl group per molecule that maybe used in accordance with the present invention are those which possess a reduced viscosity of at least about 0.1, and preferably from about 0.15 to about 15 higher. The preferred polymers of cyclic esters have a reduced viscosity of about 0.2 to about 10.

Thermoplastic saturated polymers of linear and/or cyclic esters are well known and the carboxylated saturated esters are well known and such thermoplastic saturated polymers, and particularly polymers prepared from epsilon caprolactones, have been advantageously employed as low profile additives. Reference, for example is made to U.S. Patent Nos. 3,549,586 and 3,668,178 for descriptions of thermoplastic saturated polyester low profile additives and carboxylated thermoplastic saturated polyester low profile additives prepared from cyclic esters.

Other thermoplastic saturated polyesters that are useful as low profile additives are those based on con-

densation products of, primarily, dicarboxylic acids and organic diols. Some examples of such diacids are adipic acid, isophthalic acid, terephthalic acid and the like and such glycols could be ethylene glycol, diethyl glycol, neopentyl glycol and the like.

Also suitable in certain aspects of the invention are thomoplastic polyalkyl acrylate or methacrylate low profile additives including, for example, homopolymers of methyl methacrylate, ethyl methacrylate, butyl methacrylate, methyl acrylate, ethyl acrylate; copolymers of methyl methacrylate and lower alkyl esters of acrylic and methacrylic acids, and copolymers of methyl methacrylate with minor amounts of one or more of the following: lauroyl methacrylate, isobornyl methacrylate, acrylamide, hydroxyethyl methacrylate, styrene, 2-ethylhexyl acrylate, acrylonitrile, methacrylic acid, polystyrene, styrene copolymers, such as styrene/butadiene copolymers, cellulose acetate butyrate, alkylene oxide polymers, urethane polymers, and the like.

Molecular weight of the alkyl acrylate or methacrylate polymers useful in the invention may vary over a wide range from 10,000 to 1,000,000 and preferably from 25,000 to 500,000.

Urethane polymers that can be employed in this invention, alone or as mixtures with other low profile additives, are broadly structured and some examples can be found in U.S. Patent No. 4,035,439; EP 74-746; and U.S. Patent No. 4,421,894.

The low profile additives may usually be employed in the compositions of the invention in proportions from about 1 to 25 weight percent, and preferably from about 5 to 20 weight percent, based upon the total weight of thermosetting resin, low profile additive and other reactive components.

The low profile additive can function alone or in combination with other thickening agents, as a thickening contributor to the flow characteristics of the resin.

5 The thin film may be characterized as non-pourable. Optionally, the film may be tacky as well. This condition can be achieved in a number of ways. Many thermosetting resins are solids at about 23°C. and many of them are liquids at this temperature. Both kinds of
10 resins can be made fluid non-pourable and tacky. For example, a resin that is solid and a resin that is liquid can be combined to form a mixed resin system that is non-pourable and tacky. In addition, a solid or liquid thermosetting resin can have incorporated in it a variety of diverse materials that will render the resin
15 fluid non-pourable at conventional handling temperature conditions and fluid non-pourable and tacky at room temperature (about 15-37°C.). Conventional handling temperatures are defined as a temperature of between about
20 -20°C. to about 43°C.⁷

Typical formulations of the invention are set forth in the following tables.

A typical resin formulation comprises the following:

⁷ This range reflects the fact that material handling can require low temperature storage to preclude premature reaction of the thermosetting resin system and relatively high temperatures because the film may be used on a hot factory floor.

Component	Typical Components	Range (%w/w)
Resin		
A mixture of di- and multi-functional resins selected to give a desired level of viscosity, tack and glass transition temperature.	Novolac Epoxy Bis A epoxy Bis F epoxy Tris epoxy Brominated epoxy	5-60
Fire Retardant Fillers		
Filler(s) that enhances the fire retardancy of the formulation.	Decabromobiphenyl Melamine pyrophosphate	0-40
Wetting Agent		
Selected to promote complete wetting of filler by the resin component.	Non-ionic Surfactant	0.0-1.0
Toughener		
An elastomeric material selected to improve durability	ABS Polymers Silicone Polymers	0.0-10.0
Filler		
Amorphous silica particulates added to refine cured CTE.	Amorphous Silica	25-90
Curing Agent		
Amine, phenolic and/or homopolymerization catalysts	Aromatic Amines, Guanides, Novolacs, Imidazoles, Imidazole Salts, Phosphines.	50-125% Stoichiometry, 0.01-2.5% Catalyst
Thixotrope		
Flow control agent	Fumed Silica Treated Clays	0.0-5.0

Specific representative illustrations of such film formulations are the following:

Component	Weight %			
	Adhesive A	Adhesive B	Adhesive C	Adhesive D
Epon 828 (1)	8.5	---	---	---
Tactix 742 (2)	12.7	---	---	---
Component	Weight %			
	Adhesive A	Adhesive B	Adhesive C	Adhesive D
Tactix 695 (3)	12.7	---	---	---
DEN 438 (4)	0.8	21.6	16.4	38.8
Epiclon 830S (5)	5.6	---	---	---
MY 721 (6)	---	5.0	3.8	---
PC 1344 (7)	---	0.2	0.1	0.4
Blendex 311 (8)	8.5	5.0	3.8	---
Novacite 550 (9)	42.4	---	---	---
GP 31 (10)	---	6.2	---	---
Teco-Sil 200F (11)	---	55.6	70.1	27.1
TS 720 (12)	2.6	0.6	1.2	1.2
4,4'-DDS (13)	5.4	5.1	3.9	---
Dicy (14)	0.9	0.9	0.7	---
BTDA (15)	---	---	---	31.4
2-MI-Azine (16)	---	---	---	1.2
Total	100.0	100.0	100.0	100.0
% Resin	40.3	26.6	20.3	38.8
% Wetting Agent	0.0	0.2	0.1	0.4
% Toughener	8.5	5.0	4.2	0.0
% Filler	42.4	61.8	70.1	27.1
% Thixotrope	2.6	0.6	1.2	1.2

Notes:

(1) Bis A based resin, Shell Chemical Co.	(5) Bis F resin, Dainippon Ink	(9) Silica powder, Malvern Corp.	(13) 4,4'-diaminodiphenyl-sulfone, Ciba Geigy
(2) Tris epoxy resin, Dow Chemical Co.	(6) Epoxidized aromatic amine, Ciba Geigy	(10) Silica powder, Harbison Walker	(14) Dicyandiamide, Air Products
(3) Toughened epoxy resin, Dow Chemical Co.	(7) Nonionic surfactant, Monsanto	(11) Silica powder, CE Minerals	(15) Benzophenone Dianhydride
(4) Epoxidized phenol novolac, Dow Chemical Co.	(8) ABS toughener, General Electric	(12) Fumed silica, Cabot	(16) Methylimidazole-Azine Catalyst

5 These resin formulations are made by conventional mixing of the components in standard mixing equipment for viscous compositions. Good results have been obtained using a Ross® Double Planetary Mixer, provided with vacuum construction and jacketing to control temperature and deaerate the mixture. Mixing is typically effected by blending the resin, unexpanded par-

ticles, elastomer components, extenders, diluents, curing agent and vacuum pumping to remove entrained air. The temperature chosen is variable depending on the viscosity of the formulation. It may be desirable to separately mix the resin and the curing agent. In such a case, the formulation may be divided up to mix the resin with some portion of the formulation to effect a well dispersed condition and do the same with the curing agent, and then combine the well dispersed mixes, so as to mix them all under conditions avoiding premature reaction. Such procedures are well within the skill of the art.

The following discussion relates to the drawings and the figures shown therein. None of the figures show true dimensions of the various components there depicted. Figure 7, which relates to a prior art process for making flat board PB's, describes unrolling glass fiber fabric from fiber glass fabric roll 111, passing continuous sheet 113 of glass fiber fabric into resin trough 115 via guide rollers 117, over guide roller 119 and under guide roller 121. The number of guides shown is symbolic and not necessarily indicative of how the resin impregnation step is specifically carried out. Trough 115 contains sufficient A-stage thermosetting resin to allow the desired impregnation of the fabric. The fabric withdrawn from trough 115 is fed through squeeze rolls 123 set to nip fabric 125 and reduce the level of resin therein. Fabric 125, containing A-stage thermosetting resin, is fed to treater 127 containing heater 133. Fabric 125 is fed over guide roller 129, past heater 133 and then over guide roller 131. In treater 127, polymerization of the A-stage resin is initiated so that the thermosetting resin in fabric sheet 135, is transformed to a

B-stage resin. Prepreg fabric sheet 135 is guided by roller 137 to collection roll 139. The prepreg fabric 135 is, at a separate station, unrolled and cut to sized individual sheets 141. They are then superimposed to form a multi-layer pre-laminate lay-up structure 143 containing copper foil on the outside top and bottom surfaces of the multiple superimposed prepreg sheets. The lay-up structure 143 is inserted into laminator 145 comprising a platen press containing upper heated platen 147 and lower heated platen 149. With pressure and heat, typically around 350°F., the B-stage resin is cured to form copper clad laminate 151. Laminate 151 is trimmed and sized to form finished laminates 153 that are then put into packages 155 and shipped to the PB producer.

Figure 1a, a side view schematic, provides a fundamental characterization of a batch process for practicing this invention. Press assembly 1 comprises an upper platen 2 and a lower platen 7. Such platens can be provided with heating capabilities such as electrical resistance heating, placed cartridge heaters, or by injection of hot gas or liquid, or a hot gas/liquid mixture to hollow or tubular interiors of each or one of platen 2 and 7. Provided between platens 2 and 7 are tool 3 and thermosetting resin film 6, metal foil 5 layup. In the usual equipment setup, tool 3 will be affixed to the bottom of platen 2 and the layup will be resting on the upper surface of platen 7. The term "tool" is intended to correspond to its definition of: "A bookbinder's hand stamp. ...A design impressed on a book cover by such a stamp." Tool 3 contains an embossed face 4 representing the male (embossed) image of a printed circuit pattern exposed to the upper surface of foil 5. When the platens are brought to-

gether, face 4 contacts the upper surface of metal foil 5, and starts to depress that upper surface. Because foil 5 is thin and inherently malleable, it is drawn downwardly into resin film 6. Because isotropic thermosetting resin film 6 is not cured or gelled and possesses the correct flow properties, it accepts penetration by metal foil 5 without significant flow of resin. As a result, foil 5 is allowed, on maximum penetration of tool 3, to impress a metal foil 5 pattern in resin film 6 that fully replicates the pattern of embossed face 4. As shown in Figure 1b, film 6 is debossed according to the pattern of foil 5 replicating the embossed pattern of face 4 affixed to tool 3. It contains the debossed grooves 5' that correspond to the embossed portions of face 4.

A significant feature that Figures 1a and 1b demonstrate is the freedom from impediments within isotropic resin film 6 to the penetration into it of metal foil 5 by compression of the platens 2 and 7. The resin film 6 contains no fiber component that is part of a woven, knitted or otherwise bonded (as in the case with some non-woven fabrics) structure, or part of a twisted yarn or continuous filament containing structure. In addition, the resin film 6 is free of other solid component that has the capacity of restricting the penetration of the metal foil into it. In addition, thermosetting resin film 6 is an adhesive in that when it is gelled, near-gelled and/or cured/post cured, it significantly bonds to metal foil 5 in contact with it during gelation and/or cure, such that the shaped debossed/embossed configuration of metal foil 5 is retained by the composite.

Figure 1c is a side view schematic that illustrates another embodiment of the invention. As noted herein,

the invention provides for a supporting surface for the resin film that is in contact with the metal foil layer. Figure 1c comprises a supporting layer 22 adhesively bonded to resin film 6. The supporting layer

5 may be a variety of materials. For example, it can be a polyolefin film or paper (typically release coated paper) support for film 6 that is kept in the composite during the curing operation and then later removed. Generally, supporting layer 22 is

- 10
- a thermoplastic resin film, such as nylon-6,6; nylon-6; nylon-4,6; polyester from polyethylene terephthalate; Kevlar™ polyaramide; polycarbonates (viz., poly (2,2-bis (1.4-oxyphenyl) propane carbonate)); polyarylates (viz., poly (2,2-

15 bis(1.4-oxyphenyl) propane terephthalate); polyimides; polyetherimides, such as Ultem™; polysulfones (see U.S. Patents No. 4,175,175 and 4,108,837), such as Udel™ and Radel™ A-400; the polyethersulfones (see U.S. Patents Nos.

20 4,008,203, 4,175,175 and 4,108,837), such as Vicrotrex™; polyarylsulfones; polyarylamideimides, such as Torlon™. and/or - a fibrous material such as a thermosetting resin impregnated glass fiber mat or web, or an unimpregnated glass cloth or web, a spunbonded polyester, polyamide or polyolefin sheet, a thermosetting resin impregnated glass fiber fabric or

25 tow prepreg mat or web, and the like.

Figure 1d, a side view schematic, depicts another

30 embodiment. In this figure, the debossed portions 5' of the laminate has been pressed through the thermosetting resin film 6 into supporting layer 22. In this case, layer 22 is a material that has the capac-

ity to yield to the impressed metal foil 5. Materials that have this capacity are thermoplastic resin films and low density fibrous structures, such as a glass fiber veil and other low density fibrous structures.

5 Figures 2 illustrate a couple of embodiments for practicing the method of the invention. Figures 2a and 2b show schematic side views of semi-continuous process for making laminates of the invention. In Figure 2a, semi-continuous unit 8 involves the feeding
10 of thermosetting resin 9 to a pair of calendar rolls 10 that continuously form thermosetting resin film 11. Film 11 contacts metal foil 12, withdrawn from metal foil roll 12, at nip and guide rolls 14. There, foil 12 and film 11 are pressured into contact and as a
15 composite film 15, they are passed through guide rolls 16 to a stamp pressing station comprising platens 17 with associated tool 18. Platens 17 are similar to platens 2 and 7 and tool 18 is similar to tool 3. Platens 17 are put into the closed position, and com-
20 posite 15 is compressed and debossed with curing, near gelation, or gelation as described above with respect to Figure 1a. The heat treated and heat affected composite 15 is passed to cutter 20 and collected at the stack of laminated products 19 for further processing.
25 Further processing comprises trimming and eventually modifying the metal foil layer to make laminates 19 suitable for PB applications.

 Figure 2b differs from Figure 2a in supplying supporting layer 22 withdrawn from roll 25 to nip and
30 guide rolls 14. In this case, the resulting three-layer composite film 23 is fed through guide rolls 16 to the stamp pressing station comprising platens 17 with associated tool 18, as described above. After

cutting the laminate at cutter 20, the individual laminates 24 are collected.

5 In carrying out the above process, it may be found more desirable to minimize the amount of time that the composite films 15 or 23 are kept in the stamping press. The easiest way of shortening that process step is to heat the composite film to a temperature where the thermosetting resin reacts to a higher molecular weight state and advances in adhesion to the metal foil sufficiently to allow handling. This comes about when the advancement in molecular weight causes the resin to gel or reach an incipient gel state or reach a low state of cure, such that the resin has sufficient integrity to be subjected to down stream processing conditions. Once that is effected, rather than cut the laminate, the laminate can be 15 scrolled into a roll and then later unschooled, before full cure has set in, and then fed to a continuous oven where the resin is cured/fully cured. In the semi-continuous processes of Figures 2, the slowest process step is the press stamping step. By minimizing the length of time that the composites 15 or 23 are kept in the press, it is possible to substantially speed up the process. 20

25 Figures 3a and 3b show continuous process for practicing the invention. In these figures, thermosetting resin 30 is converted into film 35 by calendering the resin between calendering rolls 33. In the case of Figure 3a, film 35 contacts metal foil continuous sheet 39 withdrawn from roll 37 at nip and guide rolls 30 41 to form composite sheet 65. In the case of Figure 3b, supporting layer 63 is withdrawn from roll 64 and fed to nip and guide rolls 41 to form composite sheet 65. In each figure, the composite sheet (46,85) is

fed to debossing roll 43, which contains on its surface, one or more male versions of the printed circuit pattern that is to be molded into the foil/resin surfaces of the composites. The composite sheets are supported by rolls 45 during the debossing step. The debossed sheet (51, 67) are fed to oven 47 which in this case comprises roller surfaces 49 to support rolling composite sheet through the oven 47. Curing is effected by heating lamps 51. Other heating means may be employed, such as an electrically heated or steam heated or gas heated oven. Preferably, the oven is of the convection type to insure uniform heating and cure. Rather than curing the sheets (53,67) in oven 47, the sheets may be brought to gel or near-gel conditions, and later cured in a separate oven. Such technique will speed up the process considerably. The gelled, near-gelled or cured sheet (53,67) may be cut to size by knife 55, the cut laminates 57 are stacked for further processing.

Figure 4 is a test printed board 80 that contains grooved circuit lines such as 84, 86, 93, and the like, and sockets 81, 85, 87, 89 and 91 for chip and other device placement. Board 80 contains a plurality of holes through it such as at 90. Board 80 illustrates the 3 dimensional nature of the debossed lines and the sockets which aid in solder displacement and alignment of devices in the board. In the case of Figure 4, the whole of the top surface of board 80 is clad in metal foil, preferably copper. Figures 4a, 4b, and 4c show side views of board 80 taken along lines 4a-4a, 4b-4b, and 4c-4c. They show the distinction between the sockets 89, 85 and 91 to the grooves as in the case of 84 and 93. Needless to say, the characterization of grooves in Figures 4b and 4c

greatly magnify for visual convenience the size of the grooves. Figure 4d shows, in addition, a layer 95 of a compressed cured resin impregnated fiber glass fabric prepreg, as a supporting layer for the composite of the invention.

Figure 5a illustrates one or several embodiments removing metal foil clad from the stamped composite shown in Figures 1-4. In Figure 5a, a cured debossed precursor board 108 (side view shown) of the invention containing cured resin 6 to which is bonded metal foil 5 according to the invention, is fed to one or more abrading devices. In the case of Figure 5a, the precursor board 108 is fed to grinding wheels 100 and 101 and then to belt sander 102 to remove the top surface 110 of board 108. Belt sander 102 comprises sanding belt 103 driven around rolls 105, and passing over deflection plate 107. As point out above, such abrasion can be eliminated or minimized by first printing a release agent through a silk screen in which the desired metal plated pattern for the board is masked. A suitable release agent is a silicone fluid release agent, and the like. Then the metal foil is placed on top of the uncured resin film, and registered to correspond to the debossing pattern of the tool. When the tool compresses the metal foil film, the debossed portion of the foil without release agent adheres to the debossed thermosetting resin and on gelation and/or curing of the resin, a secure bond is created between the resin film and the metal foil at the debossed portions only. As a result, a slight abrasion of the surface of the foil clad board with an abrasion tool or with a pressurized stream of water is all that is needed to remove the unbonded, non-debossed (i.e., the embossed portions of the debossed board) metal foil,

leaving the cured resin surface 112 free of metal foil exposed.

5 This is shown in Figure 5b, removal of metal foil at 110 leaves a printed circuit in the grooves 5' and the sockets (not shown) and foil clear embossed sections 112, in board 114.

10 Figure 6 is a top view of a PB made from the clad-
ded precursor board 80 of Figure 4. Figures 6a, 6b,
6c, and 6d, respectively, are cut away side views
taken along lines 6a-6a, 6b-6b, 6c-6c and 6d-6d. Chip
15 devices 81a, 85a, 87a, 89a, and 91a have their leads
located within the socket in a pool of solder, there
by assuring that regardless of any irregularity in
lead size, all of the leads will be adequately made
part of the circuit. As shown in Figures 6a, 6b, 6c
and 6d, foil cladding resides only in debossed areas
of the board.

**Claims:**

1. A thin film printed board precursor containing a laminate of a dielectric thermosetting resin film layer and a heat and electrically conductive metal foil layer in direct adhesive bonding with a side of the resin film, optionally containing a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer, wherein the dielectric thermosetting resin layer has an unimpeded thickness that is at least equal to that of the foil layer bonded to it.

2. The thin film printed board precursor of claim 1 wherein the electrically conductive metal foil layer is deposited or wrought foil and has an uniform thickness between about 0.1 mil (2.54×10^{-4} cm) to about 20 mils (5.08×10^{-2} cm); varying ± 10 percent for deposited foils and ± 5 percent for wrought foils.

4. The thin film printed board precursor of claim 3 wherein the dielectric thermosetting resin film has

a) an uniform areal thickness ranging from about 1 to about 250 mils (about 0.00254 cm to about 0.635 cm) as calculated from the weight of resin film for a given area;

b) with minimum and maximum thicknesses not exceeding the deviation factor set forth in Table A.

Table A

Range in mils	Deviation Factor
1 to 5	± 1 mil (± 0.00254 cm)
5 to 10	± 2 mils (± 0.00508 cm)
10 to 250	$\pm 20\%$

c) low flow at a broad temperature range;



- d) the ability to cure, gel, or near-gel, at temperatures from about 20°C. to about 250°C., in less than about 7 days and more than 1 second; and
- e) a low dielectric constant in the thermoset state.

5

5. The thin film printed board precursor of claim 1 wherein the foil surface and the resin film bonded to it possess a debossed pattern characterizing a printed circuit.

10

6. The thin film printed board precursor of claim 2 wherein the foil surface and the resin film bonded to it possess a debossed pattern characterizing a printed circuit.

15

7. The thin film printed board precursor of claim 3 wherein the foil surface and the resin film bonded to it possess a debossed pattern characterizing a printed circuit.

20

8. The thin film printed board precursor of claim 4 wherein the foil surface and the resin film bonded to it possess a debossed pattern characterizing a printed circuit.

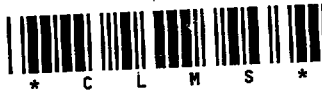
25

9. The thin film printed board precursor of claim 1 wherein the dielectric resin film has an unimpeded thickness that is at least 1.2 times thicker than the thickness of the foil film.

30

10. The thin film printed board precursor of claim 2 wherein the dielectric resin film has an unimpeded thickness that is at least 1.2 times thicker than the thickness of the foil film.

11. The thin film printed board precursor of claim 3 wherein the dielectric resin film has an unimpeded thickness that is at least 1.2 times thicker than the thickness of the foil film.



12. The thin film printed board precursor of claim 4 wherein the dielectric resin film has an unimpeded thickness that is at least 1.2 times thicker than the thickness of the foil film.

5 13. The thin film printed board precursor of claim 5 wherein the dielectric resin film has an unimpeded thickness that is at least 1.2 times thicker than the thickness of the foil film.

10 14. The thin film printed board precursor of claim 6 wherein the dielectric resin film has an unimpeded thickness that is at least 1.2 times thicker than the thickness of the foil film.

15 15. The thin film printed board precursor of claim 7 wherein the dielectric resin film has an unimpeded thickness that is at least 1.2 times thicker than the thickness of the foil film.

20 16. The thin film printed board precursor of claim 8 wherein the dielectric resin film has an unimpeded thickness that is at least 1.2 times thicker than the thickness of the foil film.

25 17. The thin film printed board precursor of claim 1 wherein the dielectric resin film has an unimpeded thickness that is as much as about 25 times of the foil film.

30 18. The thin film printed board precursor of claim 2 wherein the dielectric resin film has an unimpeded thickness that is as much as about 25 times of the foil film.

30 19. The thin film printed board precursor of claim 3 wherein the dielectric resin film has an unimpeded thickness that is as much as about 25 times of the foil film.

20. The thin film printed board precursor of claim 4 wherein the dielectric resin film has an unimpeded



thickness that is as much as about 25 times of the foil film.

21. The thin film printed board precursor of claim 5 wherein the dielectric resin film has an unimpeded thickness that is as much as about 25 times of the foil film.

22. The thin film printed board precursor of claim 6 wherein the dielectric resin film has an unimpeded thickness that is as much as about 25 times of the foil film.

23. The thin film printed board precursor of claim 7 wherein the dielectric resin film has an unimpeded thickness that is as much as about 25 times of the foil film.

24. The thin film printed board precursor of claim 8 wherein the dielectric resin film has an unimpeded thickness that is as much as about 25 times of the foil film.

25. The thin film printed board precursor of claim 1 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

26. The thin film printed board precursor of claim 2 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

27. The thin film printed board precursor of claim 3 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).



28. The thin film printed board precursor of claim 4 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

29. The thin film printed board precursor of claim 5 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

30. The thin film printed board precursor of claim 6 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

31. The thin film printed board precursor of claim 7 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

32. The thin film printed board precursor of claim 8 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

33. The thin film printed board precursor of claim 9 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

34. The thin film printed board precursor of claim 10 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film



is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

5 35. The thin film printed board precursor of claim 11 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

10 36. The thin film printed board precursor of claim 12 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

15 37. The thin film printed board precursor of claim 13 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

20 38. The thin film printed board precursor of claim 14 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

25 39. The thin film printed board precursor of claim 15 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

30 40. The thin film printed board precursor of claim 16 wherein the thickness of the thin laminated composite comprising the foil and the unimpeded resin film is from about one mil (0.00254 cm.) to about 250 mils (0.635 cm.).

41. The thin film printed board precursor of claim 5 wherein unimpeded resin film thickness is at least



equal to the depth of debossment of the metal foil into the resin film.

5 42. The thin film printed board precursor of claim 6 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

10 43. The thin film printed board precursor of claim 7 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

44. The thin film printed board precursor of claim 8 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

15 45. The thin film printed board precursor of claim 13 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

20 46. The thin film printed board precursor of claim 14 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

25 47. The thin film printed board precursor of claim 15 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

30 48. The thin film printed board precursor of claim 16 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

49. The thin film printed board precursor of claim 21 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.



50. The thin film printed board precursor of claim 22 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

5 51. The thin film printed board precursor of claim 23 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

10 52. The thin film printed board precursor of claim 24 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

15 53. The thin film printed board precursor of claim 29 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

20 54. The thin film printed board precursor of claim 30 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

55. The thin film printed board precursor of claim 31 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

25 56. The thin film printed board precursor of claim 32 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

30 57. The thin film printed board precursor of claim 37 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

58. The thin film printed board precursor of claim 38 wherein unimpeded resin film thickness is at least



equal to the depth of debossment of the metal foil into the resin film.

5 59. The thin film printed board precursor of claim 39 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

10 60. The thin film printed board precursor of claim 40 wherein unimpeded resin film thickness is at least equal to the depth of debossment of the metal foil into the resin film.

15 61. The thin film printed board precursor of claim 1 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

20 62. The thin film printed board precursor of claim 2 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

25 63. The thin film printed board precursor of claim 3 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

30 64. The thin film printed board precursor of claim 4 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

65. The thin film printed board precursor of claim 5 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermo-



plastic polymer in contact with the other side of the resin layer.

5 66. The thin film printed board precursor of claim 6 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermo-plastic polymer in contact with the other side of the resin layer.

10 67. The thin film printed board precursor of claim 7 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermo-plastic polymer in contact with the other side of the resin layer.

15 68. The thin film printed board precursor of claim 8 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermo-plastic polymer in contact with the other side of the resin layer.

20 69. The thin film printed board precursor of claim 9 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermo-plastic polymer in contact with the other side of the resin layer.

25 70. The thin film printed board precursor of claim 10 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermo-plastic polymer in contact with the other side of the resin layer.

30 71.. The thin film printed board precursor of claim 11 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermo-plastic polymer in contact with the other side of the resin layer.

72. The thin film printed board precursor of claim 12 wherein the laminate contains a supporting layer



comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

5 73. The thin film printed board precursor of claim 13 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

10 74. The thin film printed board precursor of claim 14 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

15 75. The thin film printed board precursor of claim 15 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

20 76. The thin film printed board precursor of claim 16 wherein the laminate contains a supporting layer comprising one or more of fiber, fabric and thermoplastic polymer in contact with the other side of the resin layer.

25 77. The thin film printed board precursor of claim 1 wherein the thermosetting resin film has the following properties:

- 30 a) it shapes by stamping and compression molding;
b) it provides a dielectric substrate;
c) it is sufficiently uniform in thickness to provide consistent heat shaping capability across the breadth of the film, and the thickness is sufficient to accept the shape imposed by the shaping process;



- d) it can be molded by compression or stamp molding without the need for constraining flow at the edges of the resin film;
- 5 e) it possesses low flow over a broad temperature range so that it does not flow uncontrollably while undergoing cure conditions, and when placed under pressure by impressing a mold that contains male or female surfaces comprising grooves, sockets and protuberances on it, only the portions that are superimposed over a groove or socket in the case of a female mold, or over a protuberance in the case of a male mold, will be caused to flow because of pressure imposed on the film; and
- 10 f) it gels, near-gels or cures.
- 15 78. The thin film printed board precursor of claim 2 wherein the thermosetting resin film has the following properties:
- a) it shapes by stamping and compression molding;
- b) it provides a dielectric substrate;
- 20 c) it is sufficiently uniform in thickness to provide consistent heat shaping capability across the breadth of the film, and the thickness is sufficient to accept the shape imposed by the shaping process;
- d) it can be molded by compression or stamp molding
- 25 without the need for constraining flow at the edges of the resin film;
- e) it possesses low flow over a broad temperature range so that it does not flow uncontrollably while undergoing cure conditions, and when placed under pressure by impressing a mold that contains male or female surfaces comprising grooves, sockets and protuberances on it, only the portions that are superimposed over a groove or socket in the case of a female mold, or over a protuberance in the case of a
- 30



male mold, will be caused to flow because of pressure imposed on the film; and

f) it gels, near-gels or cures.

5 79. The thin film printed board precursor of claim 3 wherein the thermosetting resin film has the following properties:

a) it shapes by stamping and compression molding;

b) it provides a dielectric substrate;

10 c) it is sufficiently uniform in thickness to provide consistent heat shaping capability across the breadth of the film, and the thickness is sufficient to accept the shape imposed by the shaping process;

d) it can be molded by compression or stamp molding without the need for constraining flow at the edges of the resin film;

15 e) it possesses low flow over a broad temperature range so that it does not flow uncontrollably while undergoing cure conditions, and when placed under pressure by impressing a mold that contains male or female surfaces comprising grooves, sockets and protuberances on it, only the portions that are superimposed over a groove or socket in the case of a female mold, or over a protuberance in the case of a male mold, will be caused to flow because of pressure imposed on the film; and

20 f) it gels, near-gels or cures.

80. The thin film printed board precursor of claim 4 wherein the thermosetting resin film has the following properties:

30 a) it shapes by stamping and compression molding;

b) it provides a dielectric substrate;

c) it is sufficiently uniform in thickness to provide consistent heat shaping capability across the



breadth of the film, and the thickness is sufficient to accept the shape imposed by the shaping process;

d) it can be molded by compression or stamp molding without the need for constraining flow at the edges of the resin film;

e) it possesses low flow over a broad temperature range so that it does not flow uncontrollably while undergoing cure conditions, and when placed under pressure by impressing a mold that contains male or female surfaces comprising grooves, sockets and protuberances on it, only the portions that are superimposed over a groove or socket in the case of a female mold, or over a protuberance in the case of a male mold, will be caused to flow because of pressure imposed on the film; and

f) it gels, near-gels or cures.

81. The thin film printed board precursor of claim 77 wherein the resin contains a low profile additive.

82. The thin film printed board precursor of claim 1 wherein the thin resin film is a thermosetting resin that is directly adhered to the foil, which thermosetting resin is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,

(i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.

83. The thin film printed board precursor of claim 2 wherein the thin resin film is a thermosetting resin that is directly adhered to the foil, which thermosetting resin is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,



(i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.

5 84. The thin film printed board precursor of claim 3 wherein the thin resin film is a thermosetting resin that is directly adhered to the foil, which thermosetting resin is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,

10 (i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.

15 85. The thin film printed board precursor of claim 4 wherein the thin resin film is a thermosetting resin that is directly adhered to the foil, which thermosetting resin is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,

20 (i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.

25 86. The thin film printed board precursor of claim 5 wherein the thin resin film is a thermosetting resin that is directly adhered to the foil, which thermosetting resin is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,

30 (i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.



87. The thin film printed board precursor of claim 6 wherein the thin resin film is a thermosetting resin that is directly adhered to the foil, which thermosetting resin is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,

(i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.

88. The thin film printed board precursor of claim 7 wherein the thin resin film is a thermosetting resin that is directly adhered to the foil, which thermosetting resin is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,

(i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.

89. The thin film printed board precursor of claim 8 wherein the thin resin film is a thermosetting resin that is directly adhered to the foil, which thermosetting resin is, when made independent of the metal foil, moldable without edge flow constraints, and contains, as its major ingredients,

(i) a thermosetting resin that advances in molecular weight without forming a significant volatile by-product and

(ii) a flow control component.

90. The thin film printed board precursor of claim 82 wherein the thermosetting resin film employs as the flow control agent one or more of —

i) one or more electronic grade fillers;



- ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;
- iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin matrix;
- iv) a thixotrope.

91. The thin film printed board precursor of claim 83 wherein the thermosetting resin film employs as the flow control agent one or more of —

- i) one or more electronic grade fillers;
- ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;
- iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin matrix;
- iv) a thixotrope.

92. The thin film printed board precursor of claim 84 wherein the thermosetting resin film employs as the flow control agent one or more of —

- i) one or more electronic grade fillers;
- ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;
- iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin matrix;
- iv) a thixotrope.

93. The thin film printed board precursor of claim 85 wherein the thermosetting resin film employs as the flow control agent one or more of —

- i) one or more electronic grade fillers;
- ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;



iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin matrix;

iv) a thixotrope.

5 94. The thin film printed board precursor of claim 86 wherein the thermosetting resin film employs as the flow control agent one or more of —

i) one or more electronic grade fillers;

10 ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;

iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin matrix;

iv) a thixotrope.

15 95. The thin film printed board precursor of claim 87 wherein the thermosetting resin film employs as the flow control agent one or more of —

i) one or more electronic grade fillers;

20 ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;

iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin matrix;

iv) a thixotrope.

25 96. The thin film printed board precursor of claim 88 wherein the thermosetting resin film employs as the flow control agent one or more of —

i) one or more electronic grade fillers;

30 ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;

iii) an elastomer-type polymer that provide discrete elastomer phases (second phases) in the thermosetting resin matrix;



iv) a thixotrope.

97. The thin film printed board precursor of claim 89 wherein the thermosetting resin film employs as the flow control agent one or more of —

- 5 i) one or more electronic grade fillers;
- ii) a thermoplastic resin that is soluble or partially soluble in the thermosetting resin;
- iii) an elastomer-type polymer that provides discrete elastomer phases (second phases) in the
- 10 thermosetting resin matrix;
- iv) a thixotrope.